

Advances in the removal of precursors of disinfection by-products by ultraviolet-coupled advanced oxidation processes

Lan Ma, Jianguang Liu*

School of Municipal and Environmental Engineering, Shandong Jianzhu University, Jinan 250101, China,
Tel. +86 139-5311-8255; email: liujlg@126.com (J. Liu), Tel. +86-531-86361857; email: 764851369@qq.com (L. Ma)

Received 27 March 2021; Accepted 30 May 2021

ABSTRACT

Disinfection is an indispensable water treatment process to kill pathogens in water and prevent water-borne diseases. However, the disinfection by-products generated in the process have become the main cause of threats to human health and the ecological environment. Many studies have shown that removing the precursors of disinfection by-products is currently one of the most effective methods to reduce the production of disinfection by-products. Ultraviolet-coupled advanced oxidation processes can generate strong oxidizing free radicals through ultraviolet light activation to efficiently remove disinfection by-product precursors. It makes up for the deficiencies of traditional oxidation technology, has important significance in reducing the generation potential of disinfection by-products, and improving water quality conditions, with broad development prospects. This paper reviews the mechanisms and advances of several UV-coupled advanced oxidation processes for the treatment of disinfection by-product precursors, UV/ozone (UV/O₃), UV/hydroperoxide (UV/H₂O₂), UV/persulfate (UV/PS), UV/chlorine (UV/Cl₂) included. The treatment effects, advantages, and disadvantages of various advanced oxidation processes are compared, moreover, the future research directions and problems to be solved for the removal of disinfection by-products and precursors are proposed to promote the achievement of practical engineering application of UV coupled advanced oxidation processes.

Keywords: Ultraviolet; Ultraviolet-coupled advanced oxidation processes; Disinfection by-products; Precursor

1. Introduction

Disinfection is the key to ensuring the safe use of municipal drinking water. Chlorination disinfection reduces the incidence of water-borne diseases, for instance, cholera, typhoid fever, and dysentery [1–3]. It has the advantages of low economic cost, simple operation, and long-lasting disinfection effect, which is currently the most commonly used disinfection method in water plants. However, when the disinfectant (e.g., chlorine or chloramine) reacts with organic matter or inorganic anions (e.g., Br⁻ and I⁻) in the water, the disinfection by-products (DBPs) such as halogenated organic matter with toxicity will be generated [4].

In 1974, Dutch water chemist Rook discovered that the content of chloroform in drinking water disinfected with chlorine was higher than that in raw water, which makes trihalomethanes (THMs) the first disinfection by-product to be found in drinking water. In 1976, the National Cancer Institute of the United States classified CHCl₃ as a carcinogen based on animal studies. Chloroform is usually one of the final products of chlorination and chloramine disinfection in drinking water, which is the most frequent DBPs among THMs, because of its high stability when it coexists with chlorine and chloramine [5]. By the turn of that decade, THMs were tightly regulated in the USA at 100 µg L⁻¹ because of its potential toxicity and the risk of cancer, especially bladder cancer [6]. A second disinfection

* Corresponding author.

by-product, haloacetic acid (HAA), was then tested in drinking water at levels comparable to THMs [6]. Later, halogenated acetonitrile (HAN), as a very important nitrogen disinfection by-product (N-DBPs), was also detected in chlorinated natural water [7]. The maximum contaminant levels of THMs are 80, 100, and 100 $\mu\text{g L}^{-1}$ and those of HAAs are 60, 25, and 60 $\mu\text{g L}^{-1}$ in the U.S., European Union, and China, respectively. Thereinto, dimethylnitrosamine (NDMA) has a 10 ng L^{-1} notification level in California [8], and WHO lists a 100 ng L^{-1} guideline value for NDMA. The permissible limits set by various countries for DBPs in drinking water are shown in Table 1.

Disinfection by-products are “tri-causing” toxic substances that are carcinogenic, teratogenic, and mutagenic to the human body [9]. As several typical disinfection by-products, the sum of THMs, HAAs and HAN exceeds 80% of the total halogenated disinfection by-products [10]. Although various DBPs have their characteristics, their control methods are similar in terms of removal: ① Use alternatives to disinfectants; ② Enhance removal of precursors; ③ Remove DBPs themselves. The first two control the generation of DBPs from the source by changing the water plant process, disinfection mode, or optimising the disinfection working condition. For example, in recent years, the application of activated carbon adsorption and advanced oxidation technology based on ozone or ultraviolet has shown results in removing the precursors of DBPs [11]. The last refers to the use of physical adsorption, chemical oxidation, and biodegradation to remove the already generated DBPs, the use of adsorption, membrane filtration (e.g., RO, NF, UF, MF, etc.), ion exchange, and other technologies included [12].

The Stage 2 disinfectants and disinfection by-product (D/DBP) rule of the United States recommended the use of enhanced coagulation, granular activated carbon adsorption, and membrane separation as three methods for removing the precursors of DBPs. The first stage of implementing the D/DBP regulations lists enhanced coagulation as the most important method for controlling natural organic matter. Beauchamp et al. [13] proposed that, although water quality conditions varied with season, when the dosage of alum/ UV_{254} stoichiometric dose was $180 \pm 25 \text{ mg alum cm/L}$, the process could always achieve the goal of removing DBP precursors to the maximum extent. However, the above-mentioned technologies usually cannot make organic matter mineralisation thoroughly [14,15]. Besides, they can only remove large molecular weight and hydrophobic organic pollutants in water. However, hydrophilic organic pollutants have stable chemical structure, a long half-life, and obvious bioaccumulation. Traditional physical adsorption and chemical oxidation methods are usually difficult to meet the treatment requirements and may generate more toxic DBPs like bromate. The advanced oxidation processes (AOPs) proposed by Glaze and Kang [16] in the 1980s can effectively deal with difficult-to-degrade organic pollutants in water, which has been widely applied in the field of water treatment. AOPs generate different free radicals, including hydroxyl radicals ($\cdot\text{OH}$) and active chlorine substances (RCS) ($\text{Cl}\cdot$, $\text{Cl}_2\cdot^-$, $\text{ClO}\cdot$) [17–19], and then uses the strongly oxidising properties of free radicals to remove most of the contaminants that cannot be removed by conventional treatment processes. Because

of its mild reaction conditions, simple operation, as well as controllability, it is gradually being applied to water treatment.

The ultraviolet-coupled advanced oxidation processes (UV-AOPs) do not require an additional solution, have broad-spectrum sterilization, will not cause secondary pollution to the treated water [20]. When used in combination with other processes, it is often synergistic, and the rate of treatment is greater than the simple addition of the two processes used alone. The free radical can oxidise the precursor of disinfection by-product in water without selectivity, since the second-order reaction rate constant ranges from $10^8\text{--}10^{10} \text{ M}^{-1} \text{ s}^{-1}$ [21]. UV can be divided into four bands according to wavelength: long-wave ultraviolet UVA (315–400 nm), medium-wave ultraviolet UVB (280–315 nm), short-wave ultraviolet UVC (200–280 nm) and vacuum ultraviolet VUV (100–200 nm). The photochemical reaction must meet the following two conditions: one is that the energy of the radiated photon must be sufficient to change the chemical bond of the molecule, and the other is that the radiated photon can be absorbed by the molecule. According to the second law of photochemistry, the shorter the ultraviolet wavelength is, the higher the energy of the corresponding excited state is. However, because water molecules have a strong absorbing effect on VUV, the penetration thickness of vacuum ultraviolet in the water layer is very narrow, which also limits the large-scale application of VUV in the field of water treatment. Therefore, C-band ultraviolet (UV-C) with a wavelength between 200 and 280 nm plays a major role in promoting the generation of free radicals. Previous studies have found that persulfate can be activated by ultraviolet light with wavelengths between 193 and 351 nm, and sulfate radical production increases with wavelength reduction [22]. The highest absorption rates occur in the UVC range of 200 to 254 nm. In addition to stimulating the production of free radicals in water, UVC can make thymine in the DNA structure form T-T dimers when processing algae-containing waters, thereby losing the ability to replicate to achieve the purpose of algae killing and sterilization. To a certain extent, this avoids damage to algae cell walls caused by other oxidation methods such as pre-chlorination, thereby releasing the harm of algae toxins, and effectively reduces the generation of halogenated hydrocarbon disinfection by-product precursors in water. It should be noted that although the penetration ability of UVC is weaker than that of UVA and UVB, short-term radiation may burn the skin, and long-term or high-intensity radiation can also cause skin cancer. Moreover, ultraviolet radiation equipment is affected by many limiting factors and requires high daily management, which will increase some processing costs.

2. Disinfection by-products

2.1. Classification of DBPs

Currently, more than 700 types of DBPs have been identified and reported in the literature which account for only 30% of the total number of DBPs and the species most analyzed are THMs and HAAs [23]. The known DBPs can be roughly divided into three categories: carbon-containing

Table 1
Different national approaches to the regulation of disinfection by-products in drinking water

DBPs	Caner Group (EPA)	General toxicity	WHO	EU	US EPA	United Kingdom	Malaysia	China	Japan	Korea	Australia	New Zealand	
C-DBPs	TCM	B2	0.3		0.08		0.2	0.06	0.06	0.08		0.2	
	BDCM	B2	0.06		0.08		0.06	0.06	0.03			0.06	
	THMs	DBCm	C	0.1		0.08		0.1	0.1	0.1			0.15
		TBM	B2	0.1		0.08		0.1	0.1	0.09			0.1
		TTHM	*	0.1	0.08	0.1		*	0.1	0.1		0.25	*
		MCAA	D	0.02		0.06			0.02			0.15	0.02
	HAAs	DCAA	B2	0.05		0.06			0.05	0.03		0.1	0.05
		TCAA	C	0.2		0.06			0.1	0.03		0.1	0.2
		THAA			0.06	0.06				0.1			
	HANs	DCAN	C	0.02		0.02				0.04	0.1		0.02
TCAN										0.09			
DBAN		C	0.07		0.07				0.004	0.1		0.08	
N-nitrosamines	NDMA	Carcinogenic, cytotoxic, genotoxic, neurotoxic, liver damage	0.0001								0.0001		
			0.0001										
Inorganic disinfection by-products	Chlorite	Chlorate	0.7	0.25	1			0.7	0.6		0.8	0.8	
			0.7	0.25					0.7	0.6		0.8	0.8
			0.01	0.01	0.01	0.01	0.01		0.01	0.01		0.02	0.01
Reference	[1]	[33,120]	[1]	(EU, 1998)	(US EPA, 2009)	(Instruments, 2016)	[33]	(N.H.C.C, 2006)	(Japan, 2003)	(Agency and Water, 2018)	[1]	[1]	

*Sum of ratio of concentration of each of its respective guideline values should not exceed 1; Numerical unit is mg L⁻¹;
B2 = Probable human carcinogen based upon enough data from animal studies; C = Possible human carcinogen; D = Not classified as human carcinogenic.

disinfection by-products (C-DBPs), nitrogen-containing disinfection by-products (N-DBPs), and inorganic disinfection by-products. The classification and major precursors of disinfection by-products are recorded in Table 2.

C-DBPs mainly include THMs, haloacetic acids (HAAs), haloacetaldehydes (HALs), halo ketones (HKs), etc. THMs refers to the substitution of hydrogen atoms in methane (CH_4) by halogen atoms in water, and the main products are TCM, bromodichloromethane, bromochloromethane and tribromomethane. HAAs basically include 13 kinds of DBPs, including chloroacetic acid (MCAA), dichloroacetic acid (DCAA), trichloroacetic acid (TCAA), bromoacetic acid (MBAA), dibromoacetic acid (DBAA), tribromoacetic acid (TBAA), bromochloroacetic acid (BCAA), dibromochloroacetic acid (DBCBA), bromodichloroacetic acid (BDCAA), iodoacetic acid (MIAA), diiodoacetic acid (DIAA), chloriodoacetic acid (CIAA) and bromiodoacetic acid (BIAA) [3]. Some HAAs cytotoxic order for MBAA > DBAA > MCAA > DCAA > TCAA, genetic toxicity in order for the MBAA > MCAA > DBAA > TBAA [24]. N-DBPs mainly include halogenated acetonitriles (HANs), haloacetamide (HAM), halonitromethane (HNM), nitrosamines (NAs), and so on. There are a total of 10 kinds of substances in HANs: chloroacetonitrile (MCAN), dichloroacetonitrile (DCAN), trichloroacetonitrile (TCAN), bromoacetonitrile (MBAN), iodoacetonitrile (IAN), bromodichloroacetonitrile (BDCAN), dibromochloroacetonitrile (DBCAN), dibromoacetonitrile (DBAN), bromochloroacetonitrile (BCAN) and tribromoacetonitrile (TBAN). The most commonly detected halogenated acetonitriles in drinking water are DCAN and TCAN. The most frequently detected halogenated acetonitriles in the chlorine disinfectant water treatment process are DBAN, DCAN, TCAN, and BCAN. Inorganic disinfection by-products mainly include bromate, chlorate, and chlorite. The categories and abbreviations of three typical disinfection by-products are recorded in Table 3.

THMs and HAAs are the two main types of C-DBPs [25], China's "Drinking Water Hygiene Standards" (GB 5749-2006) stipulate that the concentration limits of TCM and TCAA in drinking water are 0.06 and 0.1 mg L^{-1} , respectively. Other types of C-DBPs, such as HALs and HKs, were detected in drinking water at concentrations ranging from 4 to 20 $\mu\text{g L}^{-1}$ and 2 to 9 $\mu\text{g L}^{-1}$, respectively. The cytotoxicity of HANs is approximately 923, 116, 92, and 34 times that of THMs, HAAs, I-THMs (iodo-trihalomethane), and HNMs, respectively [26]. For the same dose of DBPs, the cytotoxicity of HANs is the most cytotoxic [27]. It is proposed that halogenated acetonitrile accounted for 10% of the top 50 carcinogenic DBPs [28]. According to the assessment of the variation of the generation potential of dissemination by-products in the process of drinking water treatment, the

order of the comprehensive toxicity risk value caused by halogenated disinfection by-products is HANs >> HAMs > HAAs > THMs > HNMs >> I-DBPs (I-HAM and I-THM) [29]. In 2006, the World Health Organization gave the reference concentrations of DCAN, DBAN, and TCAN in tap water as 20, 70, and 1 $\mu\text{g L}^{-1}$, respectively. Maximum permissible concentrations for the same substances in Serbian national regulation are 90, 100 and 1 $\mu\text{g L}^{-1}$ [30]. N-DBPs have stronger "tri-causing", reproductive and developmental toxicity, genotoxicity, and cytotoxicity than C-DBPs. However, the standard value of such DBPs has not been determined in China, so it is necessary to strengthen the monitoring of HANs in drinking water and the study of toxicological effect in the future.

2.2. Disinfection by-product precursors

Organic or inorganic ions in the water can react with disinfectants to produce harmful substances. For example, the humic acid (HA) and bromide ions present in the water can generate trihalomethane, bromate, and aldehydes during the process of chlorination and ozone oxidation, respectively. These DBPs parent substances are known as disinfection by-product precursors [31]. The sources of precursors of DBPs can be roughly classified into the following three categories: water sources, water plant sources, and pipe network sources. Precursors in water sources include anthropogenic pollutants such as inorganic halogens, natural organics, pharmaceuticals, and personal care products (PPCPs) as well as other human-made pollutants. Pollutants from water plants mainly refer to chemical agents added from the outside, such as polymer coagulant AIDS and dissolved microbial products leaked in the biological treatment process. Fan et al. [32] used fluorescence spectroscopy to track and analyse the properties of DBP precursors to optimise the amount of DBP produced in water treatment plants. They found that hydrophobic neutral and acidic organic compounds are the prime components of soluble organic matter in the source water. Filtration is a process in increasing dissolved organic matter (DOM) content during the conventional treatment process of water plants. Therefore, the content of C-DBPs is 34.8 $\mu\text{g L}^{-1}$ from the source water rises to 42.5 $\mu\text{g L}^{-1}$ of effluent. The precursors in the pipe network are composed of protein substances produced by the rupture of microbial cells on the biofilm of the pipe wall. Therefore, natural organic matter (NOM) and DOM present in water source are the main precursors of DBPs in drinking water [33–36]. Fig. 1 briefly summarises the sources of disinfection by-product precursors in water.

NOM is produced during the biodegradation of organic substances and can be classified as humic substances

Table 2
Classification of disinfection by-products and their corresponding main precursors

Classification	DBPs	Precursors
C-DBPs	THMs, HAAs, HALs, HKs	Natural organic matter
N-DBPs	HANs, HAMs, HNMs, N-nitrosamine	Dissolved organic nitrogen
Inorganic disinfection by-products	Bromate, chlorate, chlorite, iodate	Halide ions

Table 3
Classification of several typical disinfection by-products

THMs			HAAs			HANs		
Molecular formula	DBPs	Abbreviation	Molecular formula	DBPs	Abbreviation	Molecular formula	DBPs	Abbreviation
CHCl ₃	Trichloromethane	BIM	CICH ₂ COOH	Chloroacetic acid	MCAA	CICH ₂ CN	Chloroacetonitrile	MCAN
CHBrCl ₂	Bromodichloromethane	TCM	Cl ₂ CHCOOH	Dichloroacetic acid	DCAA	Cl ₂ CHCN	Dichloroacetonitrile	DCAN
CH ₂ BrCl	Bromochloromethane	BDCM	Cl ₃ CCOOH	Trichloroacetic acid	TCAA	Cl ₃ CCN	Trichloroacetonitrile	TCAN
CHBr ₃	Tribromomethane	TBM	BrCH ₂ COOH	Bromoacetic acid	MBAA	BrCH ₂ CN	Bromoacetonitrile	MBAN
CH ₂ BrI	Bromoiodomethane	TBM	Br ₂ CHCOOH	Dibromoacetic acid	DBAA	ICH ₂ CN	Iodoacetonitrile	IAN
CHBr ₂ I	Dibromoiodomethane	DBIM	Br ₃ CCOOH	Tribromoacetic acid	TBAA	BrCl ₂ CCN	Bromodichloroacetonitrile	BDCAN
CHBrClI	Bromochloroiodomethane	BCIM	BrClCHCOOH	Bromochloroacetic acid	BCAA	Br ₂ ClCCN	Dibromochloroacetonitrile	DBCAN
CHCl ₂	Chlorodiodomethane	CDIM	Br ₂ ClCCOOH	Dibromochloroacetic acid	DBCAA	Br ₂ CHCN	Dibromoacetonitrile	DBAN
CHBrI ₂	Bromodiodomethane	BDIM	BrCl ₂ CCOOH	Bromodichloroacetic acid	BDCAA	BrClCHCN	Bromochloroacetonitrile	BCAN
CHCl ₂ I	Dichloroiodomethane	DCIM	ICH ₂ COOH	Iodoacetic acid	MIAA	Br ₃ CCN	Tribromoacetonitrile	TBAN
CHI ₃	triiodomethane	TIM	I ₂ CHCOOH	Diiodoacetic acid	DIAA			
			IClCHCOOH	Chloroiodoacetic acid	ClIAA			
			BrICHCOOH	Bromoiodoacetic acid	BIAA			

(fulvic acid (FA) and HA) and no-humic substances (carbohydrates, lipids, and amino acids) [37]. Since no-humic substances are usually thoroughly mineralised before disinfection due to their biodegradability. Therefore, humic substances become the prime precursor of disinfection by-products. The principal precursors of THMs are HA and other small molecular organic compounds, such as aniline, phenolic compounds, algae, and their metabolites, proteins, amino acids, etc. By comparing the physicochemical properties, components, and disinfection by-products generation potential (DBPsFP) of algae organic matter (AOM) as well as natural organic matter in the eutrophic water, Wang et al. [38] found that the DBPsFP of AOM in the eutrophic lake was higher than that of NOM, especially the formation potential of N-DBPs. Lin et al. [39] used coagulation technology to remove precursors of halogenated disinfection by-products, then found that AOM harmed the instability of DOM. The coagulant polyaluminum chloride can effectively reduce the generation potential of THMs and HAA in the absence of AOM, but the DBPsFP increases in the presence of AOM. Compounds with active vacant carbon atoms containing two meta hydroxyl groups on the aromatic ring or ketone compounds with active vacant carbons containing two meta hydroxyl groups are the most effective precursors for THMs. Humic substances like NOM in water are also the main precursor of HAAs. The concentration of HAAs is mainly determined by the composition ratio of HA and fulvic acid. Furthermore, the yield of HAAs after chlorination of HA is higher than that of the corresponding fulvic acid. Besides, the reaction of amino acids and phenol with chlorine can also produce HAAs.

It is worth noting that the natural organic matter in water has two sides to the generation of disinfection by-products in the advanced oxidation process. Although DOM is a major disinfection by-product precursor, several studies have confirmed that DOM can effectively inhibit the formation of bromate, which is a typical inorganic disinfection by-product during advanced oxidation [40,41]. The inhibitory mechanism of DOM on bromate production can be mainly explained as the consumption of intermediate products: ① NOM directly reacts with HOBr/OBr⁻, an important intermediate product in the process of bromate production, or generates reductive free radicals to reduce the intermediate product to Br⁻ [42]; ② DOM as a kind of free radical scavenger will consume the hydroxyl radicals in the oxidation system, break the equilibrium relationship between hydroxyl radicals and Br[•], and cut off the generation path of bromate. Experiments by Wang et al. found that when the concentration of bromide is 100 μmol L⁻¹, adding NOM (2 mg L⁻¹) to the UV/persulfate (UV/PS) reaction system can significantly inhibit the formation of bromate and prolong the lag phase [43], which was also investigated in Luo's study [44].

Dissolved organic nitrogen (DON) and hydrophobic acids are the most active parts for the formation of THMs, CHD (chloral hydrate), and HANs [45]. It is generally believed that DON is a precursor of HANs, which primarily consists of protein, nitrogen-containing heterocyclic nucleic acid, and amino acid structure in HA. Halogenated acetonitrile products are mainly DCAN. Research has further found that the hydrophilic organic acid (HIA) in

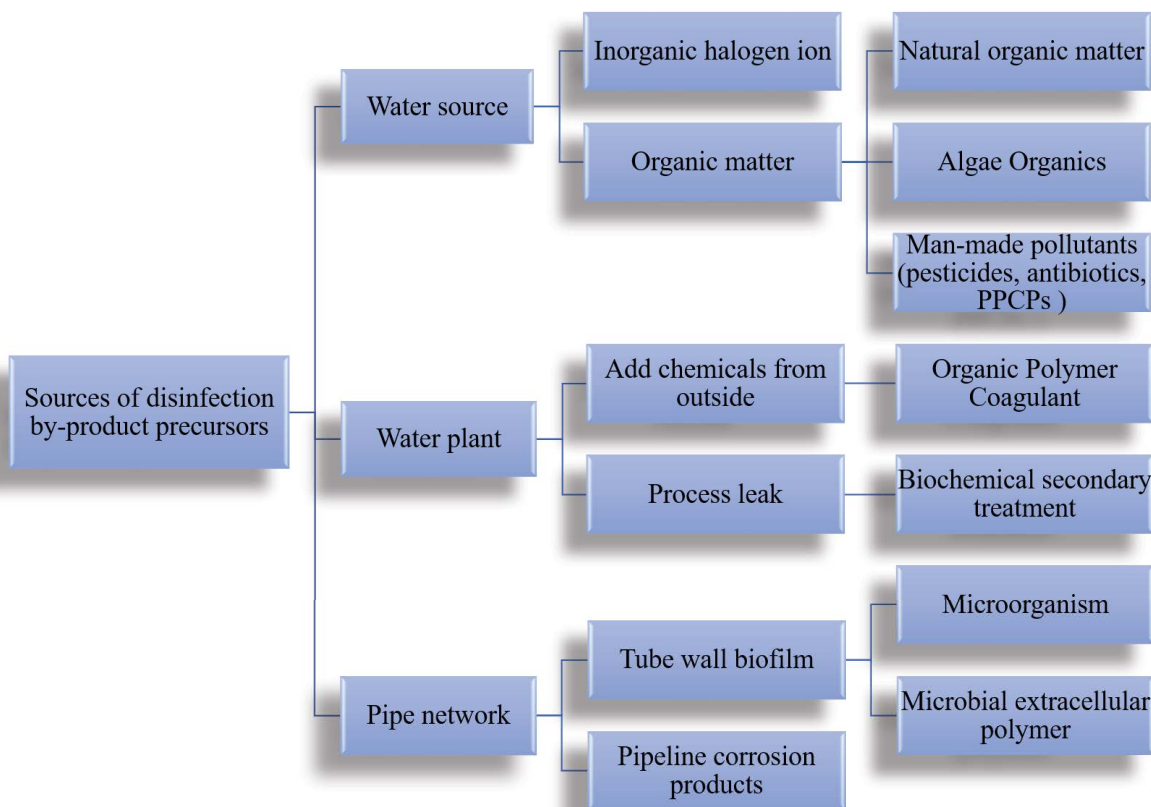


Fig. 1. Sources of precursors of disinfection by-products in water.

NOM is the prime precursor of DCAN. The main precursors of NDMA are small molecular weight (MW < 1 kDa) and large molecular weight (MW > 10 kDa) compounds of NOM [46], such as dimethylamine (DMA), diethanolamine, triethanolamine, nucleic acid, protein, etc. It is proposed that dissolved organic nitrogen compounds (e.g., dimethylamine) are the main precursors of nitrosamines [47]. Previous studies have found that pH and chloro-nitrogen ratio are the key factors affecting the reaction of dimethylamine and chloramine to produce NDMA, and the production of NDMA reaches the maximum when pH = 7 and Cl/N = 7, respectively. Compared with DON, the contribution of particulate organic nitrogen (PON) in water to the potential generation of NDMA cannot be ignored. Hu et al. [48] found that PON accounted for 12.3%–41.7% of the total bioavailable organic nitrogen in wastewater, as well as 22.0%–38.4% of the total amount of NDMA precursors. Research by Alaba et al. [49] found that it is more economical to prevent the formation of NDMA by degrading or damaging the precursors compared with degrading the already formed N-nitrosamines. The aldehydes of compounds containing acetyl functional groups have a high potential to form HAL during the disinfection process. More importantly, its reaction with free chlorine in subsequent disinfection is the principal cause of HAL formation [50].

Dissolved organic carbon (DOC), UV_{254} , SUVA, and total fluorescence index (TF) can be used as indicators to monitor the generation potential of DBPs [51]. The best-performing indicator SUVA is usually positively correlated with

the production of THMs and HAAs [52]. This approach is based on the fact that aromatic and humic compounds exhibit higher absorption properties at 254 nm than aliphatic and non-humic substances [53]. High SUVA value indicated that the main disinfection by-product precursor NOM in the aqueous matrix was mainly composed of hydrophobic organic compounds with high molar mass, whereas low SUVA value indicated that NOM was mainly composed of hydrophilic low molar mass compounds [54]. Hua et al. [55] explored the influence of the molecular weight, fluorescence composition, and SUVA ($SUVA = UV_{254}/DOC \times 100$) value of the precursor on the formation of DBPs. Experiments have confirmed that the SUVA value is a useful indicator of the monitoring of DBPs. However, when the value of SUVA is low (<2 L/mg m), DBP generation should be monitored together with the above-related properties. In addition to studying the influence of the properties of the disinfection by-product precursors on the number of DBPs, it is necessary to further evaluate the impact of water quality conditions as well as seasonal changes [32] on the toxicity risk of DBP in the future.

3. Removal of precursors of DBPs by UV-AOPs

3.1. UV/ozone

As a strong oxidant, ozone can change the molecular structure of refractory organic matter in water. It has a high treatment efficiency for PPCPs in organic wastewater. Furthermore, the degradation efficiency can reach more

than 90% [56], which can be used for decreasing the oxidative disinfection of the precursor of DBPs or trace organic compounds (TOC) [57,58]. What's more, ozone can change the reaction characteristics of disinfection by-product precursors and chlorine in the subsequent disinfection process by depending on the reaction characteristics of different reactants, to reduce the amount of disinfection by-product generation. Pre-ozonation can change the subsequent UV light transmittance and DOM's reaction characteristics to free radicals, thus reduce the negative effects of DOM on UV advanced oxidation technology [59]. Hansen et al. [60] researched the ozonisation of municipal swimming pool water. They found that ozone eliminated the reactivity of dissolved organic carbon to tap water and chlorine, thereby reducing the formation rate of total trihalomethane (TTHM). When Qi et al. [57] used ozone to oxidise the organics in wastewater, they found that the potential of trihalomethane generation decreased after the initial pre-ozonation. However, it increased to varying degrees as the degree of ozonation deepened, containing relatively high content of aromatic structures. That is, $SUVA_{254}$ and aliphatic wastewater organic matter will significantly increase the DBPsFP. Ozonation can also effectively alleviate the generation potential of disinfection by-products brought by AOM. Lin et al. [61] found that when the ozone dosage was 1.5 mg L^{-1} , the target DBPs formed by AOM were the least. Finally, ozonation can reduce the potential toxicity of subsequent disinfection processes by changing the structure and properties of organic compounds in water, even if the precursor of DBPs in water cannot be completely mineralised. Nguyen et al. [62] found that when the ozone dosage was 3.1 mg L^{-1} , DOC in Saigon River water was converted into biodegradable organic carbon (BDOC). Meanwhile, trihalomethane formation potential was reduced by about 45%.

The combined process of ultraviolet and ozone (UV/O₃) has a strong oxidising ability, which can remove pesticides, food additives, and other trace pollutants in the water. It not only does not require an additional catalyst but also is easy to operate. Based on advanced ozone oxidation, the addition of ultraviolet radiation can increase the production efficiency of $\cdot\text{OH}$ and improve the oxidation capacity of the reaction system [63,64]. In addition to inducing the production of $\cdot\text{OH}$ from O₃, UV radiation can also stimulate the production of other ground-state substances and free radicals that would not be generated in a single O₃ oxidation process. In acidic medium, direct O₃ oxidation is the main mechanism, H₂O₂ generated by this process may accumulate in the solution, because of the slow photodegradation rate. When pH > 7, regardless of ultraviolet radiation, free radical reaction is the main control factor, H₂O₂ quickly reacts with the remaining O₃, causing complex O₃ decomposition chain reaction to accelerate the chain reaction. The oxidation rate can be increased to 10~10⁴ times by combining ultraviolet radiation with ozone oxidation. It can effectively degrade the precursors of DBPs, which are primarily NOM. Petronijević et al. [65] found that the removal efficiency of NOM followed the sequence of UV/O₃ > ozonation standalone > UV irradiation standalone through the study of NOM content in groundwater and the generation potential of disinfection by-products. Cheema et al. [66] proposed that when ultraviolet radiation and ozonation were used

in swimming pool water together, ozonation eliminated the reactivity of organic matter in water to chlorine oxidation and weakened the system's demand for chlorination during disinfection, thus the generation of DBP reduced. Srithep and Phattarapattamawong [67] found that DON, as the main precursor of halogenated acetonitrile in water, could only remove 28% of its content by conventional treatment processes (coagulation, precipitation, and filtration). However, when UV/O₃ process was used, the removal rate of HAN precursors could rise to 37% when the dosage of ozone was controlled to be 5 mg L^{-1} and the irradiation dose of ultraviolet light was 220 mJ cm^{-2} . Agbaba et al. [68] found that the advanced oxidation process combined with UV/O₃/H₂O₂ could more easily modify the NOM in the aqueous matrix, that is, convert it from hydrophobic to hydrophilic, and at the same time reduce the formation potential of trihalomethane by 43% and haloacetic acid by 68%.

The disadvantage of the UV/O₃ process is that ozone is chemically unstable in aqueous solutions. When the dosage of ozone in water is 3 mg L^{-1} , the half-life is only about 30 min. Besides, the stability of ozone in water is affected by the pH value. When the pH value of the solution is high, the ozone decomposition rate is faster. Secondly, under the same conditions, the oxidation rate of ozone on different organic substances shows a significant difference from 10⁻² to 10⁴ orders of magnitude, which will lead to a phenomenon that one substance will be completely oxidized. In contrast, the other substance will be difficult to be treated when using the process to treat the precursors of DBPs. Moreover, the content of inorganic anions in water is an important factor affecting the generation potential of various DBPs. Previous studies have shown that nitrite is the main source of nitro groups in the formation of TCNM in solutions containing humus in ozone-chlorination reactions. When ozone is used to oxidize water containing nitrites, chlorination of fulcrum results in a tenfold increase in the production of TCNM. However, when the nitrite concentration was higher (3.0 mg L^{-1}), the increase of TCNMFP was not obvious. Finally, the amount of ozone should be controlled during the application of the UV/O₃ process [69], because excessive ozone will act as a free radical quenching agent in water and react with $\cdot\text{OH}$ to generate peroxide hydroxyl radical (HO₂ \cdot) with weak oxidation capacity, which reduces the oxidation capacity of the whole reaction system. Beyond that, the higher ozone dose can increase the total conversion percentage of bromine to brominated disinfection by-products (Br-DBPs) and thus increase the amount of Br-DBPs in water [65]. The photolysis rate of Br-DBPs is usually higher than that of chlorinated disinfection by-products, which will generate more toxic volatile disinfection by-products during repeated chlorination under ultraviolet irradiation [70].

3.2. UV/hydroperoxide

The mechanisms of UV and hydrogen peroxide combined process (UV/H₂O₂) to remove the precursors of DBPs can be summarised as follows: ① Direct photodegradation of ultraviolet; ② Direct oxidation of H₂O₂; ③ Indirect oxidation of decomposition of H₂O₂ into $\cdot\text{OH}$ under ultraviolet irradiation. Compared with UV/O₃, the advantages of the UV/H₂O₂ process are reflected in the following two

aspects: On the one hand, UV/H₂O₂ is a kind of green and clean oxidation process. When the bromate containing water is oxidised by the UV/H₂O₂ process, bromate with “tri-causing” (teratogenic, carcinogenic, and mutagenic) effect on the human body will not be generated. The reason is that when there is a great deal of H₂O₂ in the reactive system, the intermediate product (HOBr) reacts with HO₂ to form Br⁻ at a very rapid rate, which is much faster than that HOBr continues to be oxidised by [•]OH to form BrO₃⁻. On the other hand, UV/H₂O₂ has a high-efficiency oxidation capacity [71]. The oxidation rate of different organic substances is not much different, so it is difficult for one precursor to being degraded while another precursor is not degraded. As a strong oxidant, H₂O₂ preferentially decomposes pollutants through the phenolic ring cracking reaction [72], which can completely mineralise more refractory organic matter in water and greatly weaken the toxicity of pollutants remaining in the water. Even if complete mineralisation cannot be obtained, the UV/H₂O₂ process can also change the properties of precursors of DBPs in water and reduce the DBPsFP. Tak and Vellanki [73] proposed that when the UV irradiation intensity was 47 mJ cm⁻² min⁻¹ and the concentration of hydrogen peroxide was 0.5 mmol L⁻¹, the removal rates of DOC and UV₂₅₄ in surface water could reach 64% and 87%, respectively. Compared with O₃/H₂O₂ and O₃, when UV and H₂O₂ are used in combination, the hydrophobicity score of the effluent decreases most obviously. Simultaneously, the formation potential of trihalomethane shows the most obvious attenuation. Qian et al. [74] studied the coagulants in combination with UV/H₂O₂ oxidation method dissolving organic matter in wastewater processing, the results show that the DOC and UV₂₅₄ removal rate is higher, the removal rate of 75% and 92% respectively, the acid hydrophobic material acid, alginate and hydrophilic, and hydrophobic material removal of 92%, 87%, 70%, and 39% respectively, BOD₅/COD value increased from 0.1 to 0.52.

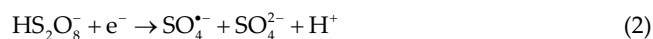
NOM has been proven to be an important contributor to the production of by-products produced during UV/H₂O₂ treatment [75]. UV/H₂O₂ process can damage the aromatic and soluble organic nitrogen components of NOM, so it has a good effect on controlling the precursor of N-DBPs. Sindelar et al. [76] evaluated the removal effect of UV/H₂O₂ process on the precursor of disinfectant by-products in high NOM matrix water, the Florida Everglades, and found that UV/H₂O₂ process was one treatment option that had shown success at reducing high levels of NOM. When the UV irradiation dose was between 21.8–22.3 J cm⁻² and the H₂O₂ concentration was 100 mg L⁻¹, the removal rates of UV₂₅₄ and DOC were about 90% and 60%, respectively. After UV/H₂O₂ peroxidation, the production of HAN, HNM, and HAM decreased by 52.1%–83.6%, 42.9%–87.3%, and 74.1%–100%, respectively. As the water toxicity was mainly contributed by HANs, the toxicity in solution was also reduced by 24.1%–82.7% [77]. Srithap and Phattarapattamawong [67] also proposed that UV/H₂O₂/O₃ and UV/H₂O₂ processes could reduce the production of HAN by 54% and 42%, respectively. During increasing the ozone dosage from 1 to 5 mg L⁻¹, the removal rate of HAN precursors rose slightly. Dalmacija et al. [30] achieved the maximum reduction of trihalomethane formation potential and HAAFP through the O₃/H₂O₂/UV process. On the other hand, controlling

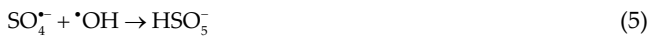
the lower dose of UV irradiation by using UV/H₂O₂ process resulted in the most effective reduction of HANFP. Compared with raw water, the percentage of bromide incorporation of DBPs has almost no change. The effect of UV/H₂O₂ on the control of NDMA precursors is better than that of the UV/ HOCl process [78–80]. UV/H₂O₂ treatment after O₃/BAC/MF/RO process can reduce the yield of NDMA formed after chlorination from 30 to 10 ng L⁻¹, the weighted toxicity of NDMA and its precursors can be controlled to the maximum extent [81]. Also as a typical precursor of nitrogen-containing disinfection by-products, the chloramphenicol (CAP), UV activated H₂O₂ preoxidation can effectively reduce the concentration of DOC in water, which is an effective process to control the generation of THMs, HAN, HNM and haloacetamide (HAcAms) in water where CAP and similar precursors commonly exist [82]. Furthermore, the UV/H₂O₂ process performed well in removing the precursors of inorganic disinfection by-products, the number of halogenated disinfection by-products was also reduced in the meantime. Compared with the oxidation of UV alone and H₂O₂ alone, [•]OH, O^{•-} and other free radicals generated by UV/H₂O₂ system could accelerate the conversion of IO₃⁻ to I⁻ in water, thereby reducing the generation of iodine disinfection by-products [83]. Similar conclusions were confirmed again by Zhang et al. [84]. After pre-oxidation with UV/H₂O₂, the production of I-THMs was reduced by 23% ± 3.5%. Moreover, the production of I-THMs after chlorination was positively correlated with the amount of H₂O₂. UV/H₂O₂ also has the function of removing odour substances in water. When Cai et al. [85] studied the formation of odour by-products in the chlorination process of major amino acids in East Taihu Lake, they found that the formation performance of odour by-products in the controlled chlorination process was better than that of UV/PS.

Generally speaking, the hydroxyl radical content in the aqueous solution will increase with the increase of the initial dosage of H₂O₂. However, it should be noted that H₂O₂ itself acts as a hydroxyl radical quencher [86]. When it is added in excess, it will react with [•]OH in the water to generate hydrogen peroxide radicals (HO₂[•]) with relatively weak oxidising power, which ultimately reduce the oxidation capacity of the reaction system [87,88].

3.3. UV/persulfate

Advanced persulfate oxidation uses SO₄^{•-} as the main active substance. Although the UV/PS system cannot directly generate [•]OH, the generated SO₄^{•-} will react with water and hydroxide to generate [•]OH. Acid-catalyzed PS reactions will occur under acidic conditions (Reaction 1-2), which is conducive to the generation of SO₄^{•-} with higher redox potential. When the reaction is in alkaline condition, SO₄^{•-} and [•]OH participate in the oxidation at the same time, but when the alkalinescence is stronger, there are two kinds of free radical degradation and mutual quenching reactions (Reaction 3-5).





UV/PS system not only has strong oxidising and non-selective $\bullet\text{OH}$, but also $\text{SO}_4^{\bullet-}$, which is more stable in water and can oxidise difficult-to-degrade micro-polluted organic matter. The UV/PS process has strong mineralisation ability and has prominent advantages in removing the precursors of DBPs. Due to the strong activation ability and stability of PS, low concentration of persulfate can be combined with ultraviolet radiation and transition metal ions to stimulate the generation of free radicals. Studies have confirmed that when the UV irradiation dose is $6,000 \text{ mJ cm}^{-2}$ and the dosage of oxidant is $1,856 \mu\text{mol L}^{-1}$, UV/PS/ Fe^{2+} , UV/PMS/ Fe^{2+} and UV/ H_2O_2 / Fe^{2+} oxidation processes can achieve TOC removal rates of 62.94%, 47.10% and 44.09%, respectively [89]. When Co^{2+} was used as a metal catalyst, the total organic carbon (TOC) removal rate of UV/PMS at 45 min was up to 99% [90]. et al. also further confirmed that metal ions (Fe^{2+} , Mn^{2+} , Zn^{2+} , Cu^{2+}) combined with UV/PS process can promote the production of sulfate radical and other free radical substances, in which UV/PS/ Cu^{2+} process can increase the removal efficiency of quaternary ammonium compounds in water by up to 37.6%. In my opinion, the improved effect of UV/PS combined with metal activator on the removal of disinfectant by-products and their precursors needs to be studied in the future.

Under neutral conditions, $\text{SO}_4^{\bullet-}$ has a higher redox potential [91,92] and a half-life of 4 s than $\bullet\text{OH}$, which prolongs the contact time between the free radical and the contaminant to be degraded, thus improving the removal effect of the technology on the precursor of DBPs in water. In contrast, $\bullet\text{OH}$ tends to oxidise precursors through non-selective dehydrogenation and addition reactions, whereas $\text{SO}_4^{\bullet-}$ is more likely to targeted electron transfer reactions and is more selective than $\bullet\text{OH}$ in degrading electron-donating groups (e.g., fluorophore groups and conjugated bonds in chromophore groups). The UV/PS advanced oxidation process has strong oxidation ability in a wide range of pH changes. Under acidic conditions, the UV/PS system is dominated by $\text{SO}_4^{\bullet-}$ oxidation degradation of organic matter. In this case, the process has selective removal of target pollutants. Under alkaline conditions, a large amount of $\text{SO}_4^{\bullet-}$ is converted to $\bullet\text{OH}$, while the degradation of target pollutants by the reaction system is dominated by the oxidation of $\bullet\text{OH}$. Also, there are sub-radical groups generated by $\bullet\text{OH}$ and $\text{SO}_4^{\bullet-}$ in the reaction system [93]. Examples are $\text{CO}_3^{\bullet-}$ (1.78 V, $k_{\text{CO}_3^{\bullet-}/\text{sulfamethoxazole}} = (2.68 \pm 0.71) \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$) [94], $\text{BrCl}^{\bullet-}$ (1.85 V) and Br^{\bullet} or $\text{Br}_2^{\bullet-}$ (2.04 or 1.09 V, $k_{\text{Br}_2^{\bullet-}/\text{salbutamol}} = (2.1 \pm 0.1) \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$) [95]. Table 4 summarizes the formation mechanism and reaction rate constants of the above kinds of free radicals.

The formation of DBPs can be effectively controlled by chloramine disinfection after UV/persulfate pre-oxidation. Chu et al. [5] studied the effect that when using UV/PS as a pre-oxidation process on the formation of THMs, HANs, and HNMs. They found that after chlorination disinfection process, the THMs content slightly

increased, while the N-DBPs (HANs and HNMs) content was slightly reduced. Increasing the pretreatment time, HANs and HNMs content increased after reducing first, most of the C-DBPs generation increase with the increase of persulfate dose, while the amount of N-DBPs began to decrease in the persulfate dosage of $10 \mu\text{mol L}^{-1}$. The study also showed that the change of pH value and the presence of nitrous compounds during the pre-oxidation process had little effect on DBPs generation. What's more, the UV/PS pre-oxidation process could significantly control the amount of HANs production. UV/PS pre-oxidation plays a vital part in reducing the generation of halogenated disinfection by-products. UV/PS pre-oxidation of water containing β -Cyclocitral decreased the yield of post-chlorinated TCM [50]. After UV/PS pretreatment of water containing 2,4-di-tert-butylphenol and other similar phenolic compounds, the production of TCM is reduced, and the toxicity is correspondingly decreased [96]. Compared with chlorination alone, chlorination disinfection followed by UV/PS pre-oxidation decreased the production of TCM, DCAN as well as CH produced by NOM respectively by 50%, 54%, and 23%. The production of TCM and DCAN continued to decrease with the prolonging of treatment time or the increase of persulfate dose [97]. Chu et al. [98] compared the inhibitory effects of UV/ H_2O_2 and UV/PS advanced oxidation processes on the yield of DBPs of water containing free amino acids under the same UV irradiation dose and oxidant concentration. The results showed that UV/PS pre-oxidation had a better control effect on HANs, although a small amount of chloroform was generated in the post-chlorination process.

In actual water treatment, the content of different substances in water will jointly affect the removal effect of UV/PS on the precursor of disinfectant by-products. For example, the high content of natural organic matter (such as HA, mass concentration $> 10 \text{ mg L}^{-1}$) in the actual water sample has a certain inhibitory effect on the treatment of organic pollutants. The unsaturated functional groups contained in natural organic matter have a certain absorption capacity for UV. Its existence will not only reduce the efficiency of UV-activated persulfate to generate free radicals, but also can compete with the target pollutants $\bullet\text{OH}$ and $\text{SO}_4^{\bullet-}$. Because $\text{SO}_4^{\bullet-}$ is more selective than $\bullet\text{OH}$ in reaction, natural organic compounds in water can capture $\bullet\text{OH}$ more effectively. The literature suggests that the reaction rate constants of NOM with $\bullet\text{OH}$ and $\text{SO}_4^{\bullet-}$ are $(1.39\text{--}4.53) \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$ and $(8.16 \pm 0.3) \times 10^7 \text{ M}^{-1} \text{ s}^{-1}$, respectively [72]. Similarly, the reaction rate constants of DOM with $\bullet\text{OH}$ and $\text{SO}_4^{\bullet-}$ are $2.8 \times 10^8 \text{ M}^{-1} \text{ s}^{-1}$ and $7.8 \times 10^7 \text{ M}^{-1} \text{ s}^{-1}$ [99]. In addition, the influence of inorganic anions in water can not be ignored. The reaction rate of Br^- with $\text{SO}_4^{\bullet-}$ is faster than that of Cl^- with $\text{SO}_4^{\bullet-}$, and similar reactions are more likely to occur to generate brominated organic compounds and Br-DBPs. When the bromide ion concentration is low, the oxidant concentration is much higher than the bromide ion concentration. Once the bromide ion changes to HOBr, it will be further oxidized to BrO_3^- immediately. Therefore, the generation rate of BrO_3^- will accelerate with the bromide ion concentration increasing. However, when bromide ion concentration is high, the HOBr generated by bromide ion oxidation will compete with bromide ion as oxidant, resulting in a decrease in the rate of bromate formation.

Table 4
Principal reactions in kinetic mode

Product	Reaction equation	Speed constant ($M^{-1} s^{-1}$)	Reference
$CO_3^{\bullet-}$	$HCO_3^- + HO^{\bullet} \rightarrow CO_3^{\bullet-} + H_2O$	8.6×10^6	[121,122]
	$CO_3^{2-} + HO^{\bullet} \rightarrow CO_3^{\bullet-} + HO^-$	3.9×10^8	[121]
	$HCO_3^- + SO_4^{\bullet-} \rightarrow CO_3^{\bullet-} + HSO_4^-$	2.8×10^6	[122,123]
	$CO_3^{2-} + SO_4^{\bullet-} \rightarrow CO_3^{\bullet-} + SO_4^{2-}$	6.1×10^6	[124]
	$HCO_3^- + Cl^{\bullet} \rightarrow CO_3^{\bullet-} + Cl^- + H^+$	2.2×10^8	[125]
	$CO_3^{2-} + Cl^{\bullet} \rightarrow CO_3^{\bullet-} + Cl^-$	5.0×10^8	[125]
	$HCO_3^- + Cl_2^{\bullet-} \rightarrow CO_3^{\bullet-} + 2Cl^- + H^+$	8.0×10^7	[125]
	$CO_3^{2-} + Cl_2^{\bullet-} \rightarrow CO_3^{\bullet-} + 2Cl^-$	1.6×10^8	[125]
	$HCO_3^- + Br_2^{\bullet-} \rightarrow CO_3^{\bullet-} + 2Br^- + H^+$	8.0×10^4	[125]
	$CO_3^{2-} + Br_2^{\bullet-} \rightarrow CO_3^{\bullet-} + 2Br^-$	3.4×10^4	[125]
	$HCO_3^- + Br^{\bullet} \rightarrow CO_3^{\bullet-} + Br^- + H^+$	1.0×10^6	[125]
	$CO_3^{2-} + Br^{\bullet} \rightarrow CO_3^{\bullet-} + Br^-$	2.0×10^6	[125]
	$HCO_3^- + BrCl^{\bullet-} \rightarrow CO_3^{\bullet-} + Br^- + HCl$	3.0×10^6	[125]
	$CO_3^{2-} + BrCl^{\bullet-} \rightarrow CO_3^{\bullet-} + Br^- + Cl^-$	6.0×10^6	[125]
	$BrCl^{\bullet-}$	$ClOH^{\bullet-} + Br^- \rightarrow BrCl^{\bullet-} + HO^-$	1.0×10^9
$Cl^{\bullet} + Br^- \rightarrow BrCl^{\bullet-}$		1.2×10^{10}	[125]
$Cl_2^{\bullet-} + Br^- \rightarrow BrCl^{\bullet-} + Cl^-$		4.0×10^9	[126]
$BrOH^{\bullet-} + Cl^- \rightarrow BrCl^{\bullet-} + HO^-$		1.9×10^8	[125]
$Br^{\bullet} + Cl^- \rightarrow BrCl^{\bullet-}$		1.0×10^8	[125]
$Br_2^{\bullet-} + Cl^- \rightarrow BrCl^{\bullet-} + Br^-$		4.3×10^6	[126]
Br^{\bullet}	$SO_4^{\bullet-} + Br^- \rightarrow Br^{\bullet} + SO_4^{2-}$	3.5×10^9	[127,128]
	$^{\bullet}OH + Br^- \rightarrow BrOH^{\bullet-}$	1.1×10^{10}	[125]
	$BrOH^{\bullet-} \rightarrow Br^{\bullet} + OH^-$	4.2×10^6	[129]
$Br_2^{\bullet-}$	$BrOH^{\bullet-} + Br^- \rightarrow Br_2^{\bullet-} + OH^-$	1.9×10^8	[129]
	$HOBr + O_2^{\bullet-} + Br^- \rightarrow O_2 + OH^- + Br_2^{\bullet-}$	3.9×10^9	[43]
	$Br_2 + HO_2^{\bullet} \rightarrow Br_2^{\bullet-} + O_2 + H^+$	1.1×10^8	[125]
	$Br_2 + O_2^{\bullet-} \rightarrow Br_2^{\bullet-} + O_2$	5.6×10^9	[125]
	$Br^{\bullet} + Br^- \rightarrow Br_2^{\bullet-}$	1.2×10^{10}	[125]
NO_3^{\bullet}	$NO_3^- + SO_4^{\bullet-} \rightarrow NO_3^{\bullet} + SO_4^{2-}$	5×10^5	[122]
NO_2^{\bullet}	$NO_2^- + SO_4^{\bullet-} \rightarrow NO_2^{\bullet} + SO_4^{2-}$	8.8×10^8	[130]
	$NO_2^- + ^{\bullet}OH \rightarrow NO_2^{\bullet} + OH^-$	1.2×10^{10}	[131]

It has been reported that trichloronitromethane (TCNM) tends to form during chlorination following UV/PS pretreatment, especially in the presence of nitrite. Bu et al. found that when the UV irradiation dose was 225 mJ cm^{-2} and the dosage of persulfate was 1.0 mmol L^{-1} , NO_2^- of 0.05 mmol L^{-1} could cause the concentration of TCNM to yield more than $2,000 \mu\text{mol L}^{-1}$ [100]. Bicarbonate can compete with the active radicals in UV/PS system and reduce the steady-state concentration of the free radicals that react with the target pollutants. When UV/PS removed sulfamethoxypyridazine (SMP) in water, the higher persulfate dose and lower pH value reduced the amount of CF, but the formation of DCAN increased. The increase of the HA content in water significantly promoted the production of TCM and DCAN [101]. Increasing the dosage of persulfate to reduce the influence of external factors on the removal of precursors of disinfection by-products by advanced oxidation technology may result in excessive sulfate content in water. The Turkish standard recommends a sulfate concentration of

25 mg L^{-1} as the threshold level for minimal disturbance to taste. When the amount of sulfate in water exceeds this value, it can cause damage to human health and cause symptoms such as diarrhea. Therefore, the dosage of persulfate should be strictly controlled. When the sulfate content in water is found to exceed the standard, nanofiltration technology can be considered to remove it [102].

3.4. UV/chlorine

Both $^{\bullet}OH$ and $^{\bullet}Cl$ are able to be produced during the operation of the UV/chlorine (UV/ Cl_2) process [103]. The selectivity of Cl^{\bullet} is stronger than that of HO^{\bullet} , and the activity of Cl^{\bullet} is higher for compounds containing rich electronic structures such as aromatic rings. Free chlorine has a higher molar absorption coefficient and quantum yield for UV light. This oxidation process has higher utilisation efficiency for UV light and also reduces the treatment cost. Some references suggest that acidic conditions are more

favorable to the formation of $\cdot\text{OH}$ and $\cdot\text{Cl}$. When the pH is less than 7.5, the free chlorine in the solution is mainly in the form of HOCl, while ClO^- is the dominant in alkaline condition. ClO^- shows a stronger free radical scavenging ability than HOCl. Wang et al. [104] pointed out that UV/ Cl_2 may exceed UV/ H_2O_2 according to the formation of free radical at low pH (<6). Several typical free radicals generated in UV/chlorine oxidation system and their corresponding reaction rate constants are summarized in Table 5.

UV/ Cl_2 advanced oxidation process is a combination of two relatively mature oxidation processes, $\text{HO}\cdot$ and $\text{Cl}_2\cdot^-$ in the system that play a significant part in the synergistic degradation of UV and chlorine [105], which can effectively remove part of the precursor of DBPs. It has the advantages of fast degradation speed, low cost, advanced equipment, simple operation and maintenance in the later stage. By observing the performance of UV/ Cl_2 on the removal of NOM, it was found that the removal rates of DOC, UVA_{254} and FI could reach 15.1%–18.6%, 80%, and 76.4%–80.8%, respectively, which were higher than that of UV alone and chlorination alone [106]. The cytotoxicity and genotoxicity of the UV/chlorine advanced oxidation process were lower than that of the UV/ H_2O_2 advanced oxidation process, which may due to the selective destruction of RCS to cytotoxic and genotoxic DBP precursors (e.g., nitrogen-containing and aromatic DBP). The yield of total organochlorine was positively correlated with the reduction of humus fluorescence in SUVA_{254} and EEM volumes, indicating the decrease of both aromatic and hydrophobicity [107].

When the UV/ Cl_2 advanced oxidation process is used to treat raw water with high actual ammonia nitrogen content, the nitrogen-containing disinfection by-product precursors in water can be effectively degraded by controlling the ratio of chlorine dosage to nitrogen content in water. Compared with the process of chlorination alone, the UV/chlorine process can reduce the amount of chlorine addition without affecting the removal effect of total nitrogen. With the increase of Cl_2/N , the content of ammonia nitrogen and TN decreases gradually. When $\text{Cl}_2/\text{N} \geq 1.6$, the removal rate of ammonia nitrogen by the UV/chlorine process was close to 100%. When $\text{Cl}_2/\text{N} < 1.6$, the degradation rate of TN by UV/chlorine process is about

30% higher than that of chlorination alone. It was found that the removal efficiency of PPCPs by the UV/chlorine process was 5%–7% higher than that by UV/ H_2O_2 process in water with high ammonia concentration (3.14 mg N/L) and the generation rates of CH and HAN were also reduced [108]. However, recent studies have shown that high concentration of ammonia will increase the formation of TCNM in the chlorination process after UV/Cl process, which needs to be paid attention to in the subsequent studies [109].

What is noteworthy is that chlorine is susceptible to the effects of water quality components to produce DBPs with biological and genetic toxicity [110]. When using the UV/monochloramine process to degrade carbamazepine in water, it was found that more DBPs were produced in filtered water as the substrate than in deionised water and potable water plant influent. The corresponding reaction rate constant increased with the increase of NH_2Cl dosage and was influenced by bicarbonate and NOM in water. Nitrogen-containing disinfection by-products were observed to decrease, but the formation potential of TCM increased [111]. Compared with chlorination alone, the UV/chlorine process promotes the formation of haloacetic acid as well as chloral hydrate when degrading NOM in water. The adsorbable organohalogen (AOX) generated by NOM in the UV/chlorine advanced oxidation process is 0.8 times higher than that generated by chlorination alone. At the same time, the cytotoxicity was 1.7 times as high as that generated by chlorination alone [106]. Liu et al. [112] found that in the process of UV/chloramine removal of NOM, the formation of DBPs was the highest in water containing HA, followed by FA and AOM. The addition of 1 mg L^{-1} bromide to the UV/chlorine process can significantly increase the formation of Br-DBPs and the total cytotoxicity and genotoxicity of DBPs [109]. Similar conclusions have been obtained by Gao et al. Due to reactive halogen species and free halogen conversion, bromide and iodide can significantly affect the degradation of HA and AOM and the formation of DBPs in the UV/Cl advanced oxidation process [113]. Dong et al. [114] and Gao et al. [113] also pointed out that when UV/ Cl_2 process was used to treat bromine-containing water and water containing AOM,

Table 5
Rate constants of reaction in UV/chlorine process

No.	Reaction	Rate constant	Reference
1	$\text{Cl}_2 + \text{H}_2\text{O} \rightarrow \text{HOCl} + \text{HCl}$	$k_d = 3.84 \times 10^{-3} \text{ M}^{-2} \text{ L}^{-2}$	[132]
2	$\text{HOCl} + h\nu \rightarrow \text{HO}\cdot + \text{Cl}\cdot$	$(1.3 \pm 0.3) \times 10^{-3} \text{ M}^{-1} \text{ s}^{-1}$	[133]
3	$\text{OCl}^- + h\nu \rightarrow \text{O}\cdot^- + \text{Cl}\cdot$	$(9 \pm 0.13) \times 10^{-3} \text{ M}^{-1} \text{ s}^{-1}$	[133,134]
4	$\text{O}\cdot^- + \text{H}_2\text{O} \rightarrow \text{HO}\cdot + \text{HO}^-$	$1.8 \times 10^6 \text{ M}^{-1} \text{ s}^{-1}$	[135]
5	$\text{Cl}\cdot + \text{Cl}^- \rightarrow \text{Cl}_2\cdot^-$	$6.5 \times 10^9 \sim 2.1 \times 10^{10} \text{ M}^{-1} \text{ s}^{-1}$	[136]
6	$\text{HO}\cdot + \text{HOCl} \rightarrow \text{H}_2\text{O} + \text{ClO}\cdot$	$2.0 \times 10^9 \text{ M}^{-1} \text{ s}^{-1}$	[19]
7	$\text{HO}\cdot + \text{OCl}^- \rightarrow \text{HO}^- + \text{ClO}\cdot$	$8.8 \times 10^9 \text{ M}^{-1} \text{ s}^{-1}$	[19]
8	$\text{HO}\cdot + \text{Cl}^- \rightarrow \text{ClOH}\cdot^-$	$4.3 \times 10^9 \sim 1.8 \times 10^{10} \text{ M}^{-1} \text{ s}^{-1}$	[19]
9	$\text{Cl}\cdot + \text{H}_2\text{O} \rightarrow \text{ClOH}\cdot^- + \text{H}^+$	$3 \times 10^2 \sim 1.8 \times 10^4 \text{ M}^{-1} \text{ s}^{-1}$	[137]
10	$\text{Cl}_2\cdot^- + \text{H}_2\text{O} \rightarrow \text{ClOH}\cdot^- + \text{Cl}^- + \text{H}^+$	$24 \text{ M}^{-1} \text{ s}^{-1}$	[136]
11	$\text{Cl}_2\cdot^- + \text{HO}^- \rightarrow \text{ClOH}\cdot^- + \text{Cl}^-$	$7.3 \times 10^6 \sim 4.5 \times 10^7 \text{ M}^{-1} \text{ s}^{-1}$	[132]

by-products of bromination disinfection increase with bromide ion concentration, so more attention should be paid.

4. Comparison of UV-AOPs on the removal of DBPs and their precursors

Through the above description of the mechanisms and advances of different UV-AOPs, the free radical generation mechanism of each process and the redox potential of the main free radicals in different systems are summarised in Table 6 and Fig. 2.

By comparing the treatment effects of the above UV-AOPs on DBPs and their precursors (Tables 6 and 7), it is found that compared with the traditional oxidation technology, the UV-AOPs has many advantages such as high oxidation efficiency, simple operation, mild reaction conditions, wide applicability and so on, which make up for the deficiencies of the traditional oxidation technology. UV-AOPs have great advantages in removing DBPs and their precursors, but they all have some disadvantages, which need to be further optimised in the later application process.

According to the information provided in Tables 7 and 8, UV/H₂O₂ is an advanced oxidation process that is green, environment-friendly, and does not produce secondary pollution. The treatment process only requires H₂O₂ feeding equipment and UV lamp source, and there is no requirement for temperature and pressure. The process has a high removal rate of chlorine-containing aromatic fatty acids, and in particular, it has a good effect on the control of odour by-products. The UV/O₃ and UV/PS processes have strong oxidation ability, which can oxidise microbial metabolites with unsaturated double bonds and difficult-to-degrade organic pollutants in water. It can effectively avoid the degradation is not complete and in the subsequent process to generate more toxic DBPs. UV/O₃ and UV/Cl₂ are easily affected by water quality components and generate other kinds of DBPs with certain risks.

5. Conclusion and prospect

In this paper, the advances of UV-AOPs for removing precursors of DBPs in water was reviewed. The conventional

treatment process is usually unable to completely mineralise the pollutants, and the treatment effect is not good, but also produces DBPs with a “tri-causing” effect. UV-AOPs degrade pollutants in water through direct photolysis and indirect oxidation of various free radicals, which makes up for the deficiency of traditional oxidation treatment and has obvious advantages in removing the precursors of DBPs.

Given the future research on UV-AOPs, it is urgent to solve the application of different influencing factors to UV-AOPs. For example, water quality changes will affect the ultraviolet transmittance, reducing the treatment efficiency, to provide a theoretical basis for UV-AOPs to remove pollutants in actual water.

5.1. Develop better techniques for removing DBPs and their precursors

The UV irradiation dosage used in the currently UV-AOPs usually has no significant effect on the removal of the DBPs produced in water, due to the low reaction rate constant ($\sim 10^8 \text{ M}^{-1} \text{ s}^{-1}$) of the halogenated disinfection by-products with $\cdot\text{OH}$ [3]. The new UV-based reduction process (UV-ARP), which effectively breaks the C-X bond by introducing reactive-reducing species [115], is particularly suitable for treating halogenated disinfection by-products that have been generated. Also, biological filtration, membrane technology (RO, NF, MF), enhanced coagulation, as well as magnetic ion exchange technology are effective methods for removing the precursors of DBPs [116]. Eliminating pre-chlorination, optimising chlorine dosage through disinfection standards, and switching to chloramine for secondary disinfection can reduce the production of DBPs [1].

5.2. Analysis of degradation pathways and product toxicity

The conversion kinetics, mechanism, and toxicity of DBP deserve further study. The structural groups of the precursors of typical DBPs in real water are studied to explain the degradation laws based on UV-AOPs. In the process of oxidation, attention should be paid not only to the precursors of DBPs but also to the toxicity of intermediate products.

Table 6
Formation mechanism of free radicals in different UV-AOPs

Process	Mechanism	Redox potential	Reference
UV/O ₃	$\text{O}_3 + \text{H}_2\text{O} + h\nu \rightarrow \text{O}_2 + \text{H}_2\text{O}_2$ $\text{H}_2\text{O}_2 + h\nu \rightarrow 2\text{OH}$	$E_{\text{HO}^\bullet/\text{H}_2\text{O}}^0 = 2.7 \text{ V}$	[63]
UV/H ₂ O ₂	$\text{H}_2\text{O}_2 + h\nu \rightarrow 2\text{OH}$	$E_{\text{HO}^\bullet/\text{H}_2\text{O}}^0 = 2.7 \text{ V}$	[138]
UV/PS	$\text{S}_2\text{O}_8^{2-} + h\nu \rightarrow 2\text{SO}_4^{\bullet-}$ $\text{SO}_4^{\bullet-} + \text{H}_2\text{O} \rightarrow \text{HSO}_4^- + \cdot\text{OH}$ $\text{SO}_4^{\bullet-} + \text{OH}^- \rightarrow \text{SO}_4^{2-} + \cdot\text{OH}$	$E_{\text{SO}_4^{\bullet-}/\text{SO}_4^{2-}}^0 = 2.5 \sim 3.1 \text{ V}$ $E_{\text{HO}^\bullet/\text{H}_2\text{O}}^0 = 2.7 \text{ V}$	[139,140]
UV/Cl ₂	$\text{HOCl} + h\nu \rightarrow \text{HO}^\bullet + \text{Cl}^\bullet$ $\text{Cl}^\bullet + \text{Cl}^- \rightarrow \text{Cl}_2^{\bullet-}$	$E_{\text{Cl}^\bullet/\text{Cl}^-}^0 = 2.2 \sim 2.4 \text{ V}$ $E_{\text{Cl}_2^{\bullet-}/2\text{Cl}^-}^0 = 2.0 \sim 2.126 \text{ V}$ $E_{\text{HO}^\bullet/\text{H}_2\text{O}}^0 = 2.7 \text{ V}$	[108,141]

Table 7
Comparison of effects of different UV-AOPs on DBPs precursors

Process	Condition	Performance	Advantage	Disadvantage	Reference
UV/O ₃	UV dose: 110 mJ cm ⁻² ; O ₃ dosage: 5 mg L ⁻¹ ; pH: 6–8; reaction time: 20 min	Formation of HAN was inhibited by 37%	<ul style="list-style-type: none"> Effective destruction of refractory and toxic organic in water Generates higher levels of •OH and reduction of THMFP 	Ozone in water is chemically unstable, prone to bromate	[33,67]
UV/H ₂ O ₂	UV dose: 292.5 mJ cm ⁻² ; H ₂ O ₂ dosage: 10 mg L ⁻¹ ; pH: 7; reaction time: 30 min	Yield of THMs decreased by more than 80% during chlorination	<ul style="list-style-type: none"> Green environmental protection, no secondary pollution, non-selective reaction Mineralization of NOM 	Utilization rate of UV is not high, and hydrogen peroxide itself is a •OH quenching agent	[33,82]
UV/PS	UV intensity: 0.1 mW cm ⁻² ; PS dosage: 1.0 mmol L ⁻¹ ; pH: 7; reaction time: 60 min	Formation rate of TCM was reduced by 38%	High mineralization efficiency of precursors, less affected by pH	SO ₄ ²⁻ is selective, residual concentrations of SO ₄ ²⁻ contaminated water sources can cause diseases such as dysentery	[142]
UV/Cl ₂	UV intensity: 1.8 mW cm ⁻² ; Cl ₂ dosage: 50 mg L ⁻¹ ; pH: 7; reaction time: 30 min	Removal rates of DOC, UV ₂₅₄ and FI ranged from 15.1%–18.6%, 80%, and 76.4%–80% respectively	Free chlorine has a higher molar absorption coefficient and quantum yield to ultraviolet light, low operating cost	Easily affected by water quality conditions to produce halogenated disinfection by-products	[106]

Table 8
Comparison of effects of different UV-AOPs on DBPs

Process	Condition	Performance	Advantage	Disadvantage	Reference
UV/O ₃	UV intensity: 0.58 mW/cm ² ; O ₃ dosage: 1.0 mg L ⁻¹ ; pH: 7; [NPYR] ₀ = 1 μmol L ⁻¹ ; reaction time: 120 s	N-nitrosopyrrolidine was completely degraded at 120 s	This method has a simple procedure, mild reaction condition	Ozone is not effective in NDMA decomposition under neutral conditions	[143,144]
UV/H ₂ O ₂	UV dose: <200 mJ cm ⁻² ; H ₂ O ₂ dosage: 10 mg L ⁻¹ ; pH: 7.4; [DCL] ₀ = 3 mg L ⁻¹ ; [TCS] ₀ = 2 mg L ⁻¹	Removal rate of diclofenac (DCL) and triclosan (TCS) reached 80%	High removal rate of chlorinated aromatic fatty acids and control the formation of odor by-products	It is difficult to treat high concentration organic wastewater	[85,145]
UV/PS	UV intensity: 58.9 μW cm ⁻² ; PS dosage: 200 μmol L ⁻¹ ; pH: 6; [DBP] ₀ = 1 μM; reaction time: 30 min	Dibutyl phthalate (DBP) removal rate was 90.6% after 30 min	Removal of halogenated organic compounds can be converted to halogen active compounds at neutral pH	Easily produce disinfection by-product NO ₃	[146]
UV/Cl ₂	UV dose: 520 mJ cm ⁻² ; free chlorine dosage: 30 mg L ⁻¹ ; pH: 7	Values of UV ₂₅₄ decreased from 0.091 to 0.06 cm ⁻¹	UV/chlorine treatment can produce high-quality water from fresh water and iodide containing water (iodide only)	UV/chlorine treatment of brominated water increases the formation of Br-DBPs	[113]

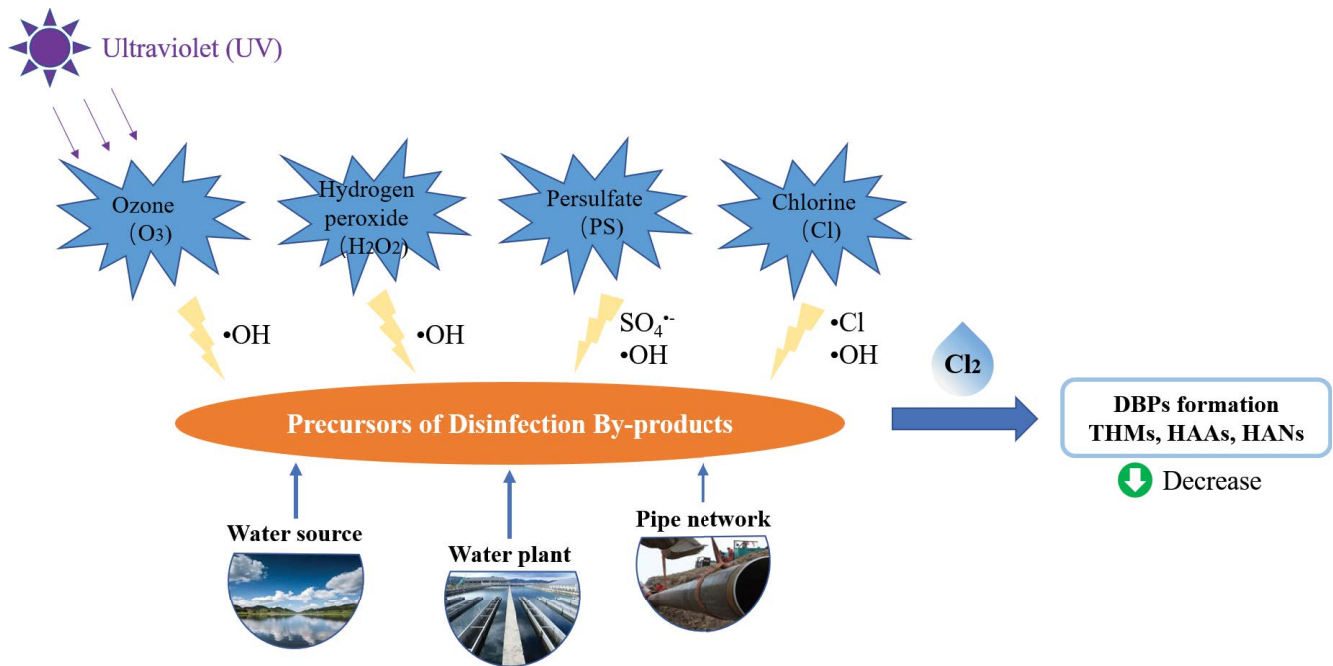


Fig. 2. Mechanism of different UV-AOPs in reducing the yield of DBPs.

Toxicity tests should be carried out at different stages of treatment, and the toxicity of residual degradation products should be evaluated. Toxicity of degradation products to aquatic organisms (such as green algae, fish and daphnia) is mainly based on the structure–activity relationships (SARs), and can be tested using the ECOSAR program, which is freely available by the U.S. Environmental Protection Agency (US EPA) [117,118]. The cytotoxicity of various DBPs was evaluated by the ratio of the production potential of disinfection by-products (in dosages) to the LC_{50} value of the corresponding Chinese hamster ovary (CHO) cells [119].

5.3. Look for a more suitable oxidant

The results show that the removal effect of UV_{254} and DOC in water matrix with high NOM content by sodium percarbonate and sodium perborate in combination with UV is similar to that of UV/H_2O_2 [76]. To develop new low-cost, green and environmentally friendly oxidants with higher utilisation rate to ultraviolet light, to produce active substances such as free radicals with stronger oxidation capacity, and to establish the reaction rate constant of related free radicals (such as $CO_3^{\bullet-}$, $HPO_4^{\bullet-}$, $SO_3^{\bullet-}$) with DBPs and precursors. Control the dosage of oxidants to achieve the best treatment effect while taking into account the economy.

5.4. Establish field-proven operating procedures

Field experiments are required to validate the practical application of the results in water supplies [113]. Future research should pay more attention to the establishment of field-proven operating procedures, from laboratory static tests to pilot tests, and to increase the engineering application value of the UV-AOPs. Systematic investigation and analysis of DBPs and their precursors in water are carried

out, and a technical system for the generation and control of DBPs in actual drinking water is constructed to reduce the occurrence of undesirable by-products and side reactions in the real water matrix.

References

- [1] M.A. Mazhar, N.A. Khan, S. Ahmed, A.H. Khan, A. Hussain, Rahisuddin, F. Changani, M. Yousefi, S. Ahmadi, V. Vambol, Chlorination disinfection by-products in municipal drinking water – a review, *J. Cleaner Prod.*, 273 (2020) 123159, doi: 10.1016/j.jclepro.2020.123159.
- [2] V. Gomez-Alvarez, S. Pfaller, J.G. Pressman, D.G. Wahman, R.P. Revetta, Resilience of microbial communities in a simulated drinking water distribution system subjected to disturbances: role of conditionally rare taxa and potential implications for antibiotic-resistant bacteria, *Environ. Sci. Water Res. Technol.*, 2 (2016) 645–657.
- [3] X. Lei, Y. Lei, X. Zhang, X. Yang, Treating disinfection by-products with UV or solar irradiation and in UV advanced oxidation processes: a review, *J. Hazard. Mater.*, 408 (2020) 124435, doi: 10.1016/j.jhazmat.2020.124435.
- [4] E.D. Wagner, M.J. Plewa, CHO cell cytotoxicity and genotoxicity analyses of disinfection by-products: an updated review, *J. Environ. Sci. (China)*, 58 (2017) 64–76.
- [5] W. Chu, T. Chu, T. Bond, E. Du, Y. Guo, N. Gao, Impact of persulfate and ultraviolet light activated persulfate pre-oxidation on the formation of trihalomethanes, haloacetonitriles and halonitromethanes from the chlor(am)ination of three antibiotic chloramphenicols, *Water Res.*, 93 (2016) 48–55.
- [6] T. Bond, J. Huang, M.R. Templeton, N. Graham, Occurrence and control of nitrogenous disinfection by-products in drinking water – a review, *Water Res.*, 45 (2011) 4341–4354.
- [7] B.G. Oliver, Dihaloacetonitriles in drinking-water – algae and fulvic-acid as precursors, *Environ. Sci. Technol.*, 17 (1983) 80–83.
- [8] J. Liu, H. Lujan, B. Dhungana, W.C. Hockaday, C.M. Sayes, G.P. Cobb, V.K. Sharma, Ferrate(VI) pretreatment before disinfection: an effective approach to controlling unsaturated and aromatic halo-disinfection by-products in chlorinated and chloraminated drinking waters, *Environ. Int.*, 138 (2020) 105641, doi: 10.1016/j.envint.2020.105641.

- [9] X. Sun, M. Chen, D. Wei, Y. Du, Research progress of disinfection and disinfection by-products in China, *J. Environ. Sci. (China)*, 81 (2019) 52–67.
- [10] M.H. Banna, S. Imran, A. Francisque, H. Najjaran, R. Sadiq, M. Rodriguez, M. Hoorfar, Online drinking water quality monitoring: review on available and emerging technologies, *Crit. Rev. Env. Sci. Technol.*, 44 (2014) 1370–1421.
- [11] A.L. Srivastav, N. Patel, V.K. Chaudhary, Disinfection by-products in drinking water: occurrence, toxicity and abatement, *Environ. Pollut.*, 267 (2020) 115474, doi: 10.1016/j.envpol.2020.115474.
- [12] J. Liu, M. Zhao, C. Duan, P. Yue, T. Li, Removal characteristics of dissolved organic matter and membrane fouling in ultrafiltration and reverse osmosis membrane combined processes treating the secondary effluent of wastewater treatment plant, *Water Sci. Technol.*, 83 (2021) 689–700.
- [13] N. Beauchamp, C. Bouchard, C. Dorea, M. Rodriguez, Ultraviolet absorbance monitoring for removal of DBP-precursor in waters with variable quality: enhanced coagulation revisited, *Sci. Total Environ.*, 717 (2020) 137225, doi: 10.1016/j.scitotenv.2020.137225.
- [14] L. Wei, K. Wen, J. Lu, J. Ma, Quantification of low molecular weight oxidation by-products produced from real filtered water after catalytic ozonation with different pathways, *J. Hazard. Mater.*, 405 (2021) 124674, doi: 10.1016/j.jhazmat.2020.124674.
- [15] E. Bei, Y. Shu, S. Li, X. Liao, J. Wang, X. Zhang, C. Chen, S. Krasner, Occurrence of nitrosamines and their precursors in drinking water systems around mainland China, *Water Res.*, 98 (2016) 168–175.
- [16] W.H. Glaze, J.W. Kang, Advanced oxidation processes. Description of a kinetic model for the oxidation of hazardous materials in aqueous media with ozone and hydrogen peroxide in a semibatch reactor, *Ind. Eng. Chem. Res.*, 28 (1989) 1573–1580.
- [17] G. Cerreta, M.A. Roccamante, P. Plaza-Bolaños, I. Oller, A. Aguera, S. Malato, L. Rizzo, Advanced treatment of urban wastewater by UV-C/free chlorine process: micro-pollutants removal and effect of UV-C radiation on trihalomethanes formation, *Water Res.*, 169 (2020) 115220, doi: 10.1016/j.watres.2019.115220.
- [18] Y. Lei, S. Cheng, N. Luo, X. Yang, T. An, Rate constants and mechanisms of the reactions of Cl^{\cdot} and $\text{Cl}_2^{\cdot-}$ with trace organic contaminants, *Environ. Sci. Technol.*, 53 (2019) 11170–11182.
- [19] Y.-Q. Gao, J. Zhang, C. Li, F.-X. Tian, N.-Y. Gao, Comparative evaluation of metoprolol degradation by UV/chlorine and UV/ H_2O_2 processes, *Chemosphere*, 243 (2020) 125325, doi: 10.1016/j.chemosphere.2019.125325.
- [20] K. Song, M. Mohseni, F. Taghipour, Application of ultraviolet light-emitting diodes (UV-LEDs) for water disinfection: a review, *Water Res.*, 94 (2016) 341–349.
- [21] D.B. Miklos, R. Hartl, P. Michel, K.G. Linden, J.E. Drewes, U. Hubner, UV/ H_2O_2 process stability and pilot-scale validation for trace organic chemical removal from wastewater treatment plant effluents, *Water Res.*, 136 (2018) 169–179.
- [22] R. Hazime, Q.H. Nguyen, C. Ferronato, A. Salvador, F. Jaber, J.M. Chovelon, Comparative study of imazalil degradation in three systems: UV/ TiO_2 , UV/ $\text{K}_2\text{S}_2\text{O}_8$ and UV/ $\text{TiO}_2/\text{K}_2\text{S}_2\text{O}_8$, *Appl. Catal., B*, 144 (2014) 286–291.
- [23] J.S. Benítez, C.M. Rodríguez, A.F. Casas, Disinfection by-products (DBPs) in drinking water supply systems: a systematic review, *Phys. Chem. Earth. A/B/C/*, (2021) 102987 (in Press), doi: 10.1016/j.pce.2021.102987.
- [24] M.J. Plewa, Y. Kargalioglu, D. Vanker, R.A. Minear, E.D. Wagner, Mammalian cell cytotoxicity and genotoxicity analysis of drinking water disinfection by-products, *Environ. Mol. Mutagen.*, 40 (2002) 134–142.
- [25] S.S. Marais, E.J. Ncube, T.A.M. Msagati, B.B. Mamba, T.T.I. Nkambule, Assessment of trihalomethane (THM) precursors using specific ultraviolet absorbance (SUVA) and molecular size distribution (MSD), *J. Water Process Eng.*, 27 (2019) 143–151.
- [26] M.G. Muellner, E.D. Wagner, K. McCalla, S.D. Richardson, Y.T. Woo, M.J. Plewa, Haloacetonitriles vs. regulated haloacetic acids: are nitrogen-containing DBPs more toxic?, *Environ. Sci. Technol.*, 41 (2007) 645–651.
- [27] I.A. Ike, Y. Lee, J. Hur, Impacts of advanced oxidation processes on disinfection by-products from dissolved organic matter upon post-chlor(am)ination: a critical review, *Chem. Eng. J.*, 375 (2019) 121929, doi: 10.1016/j.cej.2019.121929.
- [28] W.H. Chu, N.Y. Gao, Y. Deng, Formation of haloacetamides during chlorination of dissolved organic nitrogen aspartic acid, *J. Hazard. Mater.*, 173 (2010) 82–86.
- [29] Y. Zhang, W. Chu, D. Yao, D. Yin, Control of aliphatic halogenated DBP precursors with multiple drinking water treatment processes: formation potential and integrated toxicity, *J. Environ. Sci. (China)*, 58 (2017) 322–330.
- [30] B. Dalmacija, D. Krčmar, T. Đurkić, M. Watson, A. Tubić, J. Agbaba, J.M. Jazić, Effect of photochemical advanced oxidation processes on the formation potential of emerging disinfection by-products in groundwater from part of the Pannonian Basin, *Water Supply*, 19 (2019) 1388–1395.
- [31] P.C. Singer, Humic substances as precursors for potentially harmful disinfection by-products, *Water Sci. Technol.*, 40 (1999) 25–30.
- [32] Z. Fan, H. Yang, S. Li, X. Yu, Tracking and analysis of DBP precursors' properties by fluorescence spectrometry of dissolved organic matter, *Chemosphere*, 239 (2020) 124790, doi: 10.1016/j.chemosphere.2019.124790.
- [33] F. Mohd Zainudin, H. Abu Hasan, S.R. Sheikh Abdullah, An overview of the technology used to remove trihalomethane (THM), trihalomethane precursors, and trihalomethane formation potential (THMFP) from water and wastewater, *J. Ind. Eng. Chem.*, 57 (2018) 1–14.
- [34] A.M. Tugulea, R. Aranda-Rodriguez, D. Berube, M. Giddings, F. Lemieux, J. Hnatiw, L. Dabeka, F. Breton, The influence of precursors and treatment process on the formation of Iodo-THMs in Canadian drinking water, *Water Res.*, 130 (2018) 215–223.
- [35] S. Tak, B.P. Vellanki, Natural organic matter as precursor to disinfection by-products and its removal using conventional and advanced processes: state of the art review, *J. Water Health*, 16 (2018) 681–703.
- [36] Y. Xiang, M. Gonsior, P. Schmitt-Kopplin, C. Shang, Influence of the UV/ H_2O_2 advanced oxidation process on dissolved organic matter and the connection between elemental composition and disinfection by-product formation, *Environ. Sci. Technol.*, 54 (2020) 14964–14973.
- [37] B.S. Karnik, S.H. Davies, M.J. Baumann, S.J. Masten, The effects of combined ozonation and filtration on disinfection by-product formation, *Water Res.*, 39 (2005) 2839–2850.
- [38] X.X. Wang, B.M. Liu, M.F. Lu, Y.P. Li, Y.Y. Jiang, M.X. Zhao, Z.X. Huang, Y. Pan, H.F. Miao, W.Q. Ruan, Characterization of algal organic matter as precursors for carbonaceous and nitrogenous disinfection by-products formation: comparison with natural organic matter, *J. Environ. Manage.*, 282 (2021) 111951, doi: 10.1016/j.jenvman.2021.111951.
- [39] J.L. Lin, A.R. Ika, Minimization of halogenated DBP precursors by enhanced PACl coagulation: the impact of organic molecule fraction changes on DBP precursors destabilization with Al hydrates, *Sci. Total Environ.*, 703 (2020) 134936, doi: 10.1016/j.scitotenv.2019.134936.
- [40] H.V. Lutze, R. Bakkour, N. Kerlin, C. von Sonntag, T.C. Schmidt, Formation of bromate in sulfate radical based oxidation: mechanistic aspects and suppression by dissolved organic matter, *Water Res.*, 53 (2014) 370–377.
- [41] Y. Liu, Y. Yang, S. Pang, L. Zhang, J. Ma, C. Luo, C. Guan, J. Jiang, Mechanistic insight into suppression of bromate formation by dissolved organic matters in sulfate radical-based advanced oxidation processes, *Chem. Eng. J.*, 333 (2018) 200–205.
- [42] J.Y. Fang, C. Shang, Bromate formation from bromide oxidation by the UV/persulfate process, *Environ. Sci. Technol.*, 46 (2012) 8976–8983.
- [43] Z. Wang, N. An, Y. Shao, N. Gao, E. Du, B. Xu, Experimental and simulation investigations of UV/persulfate treatment in presence of bromide: effects on degradation kinetics, formation of brominated disinfection by-products and bromate, *Sep. Purif. Technol.*, 242 (2020) 116767, doi: 10.1016/j.seppur.2020.116767.

- [44] C. Luo, J. Gao, D. Wu, J. Jiang, Y. Liu, W. Zhou, J. Ma, Oxidation of 2,4-bromophenol by UV/PDS and formation of bromate and brominated products: a comparison to UV/H₂O₂, *Chem. Eng. J.*, 358 (2019) 1342–1350.
- [45] Q. Zhang, W.F. Kuang, L.Y. Liu, K. Li, K.H. Wong, A.T. Chow, P.K. Wong, Trihalomethane, haloacetonitrile, and chloral hydrate formation potentials of organic carbon fractions from sub-tropical forest soils, *J. Hazard. Mater.*, 172 (2009) 880–887.
- [46] M. Sgroi, F.G.A. Vagliasindi, S.A. Snyder, P. Roccaro, N-Nitrosodimethylamine (NDMA) and its precursors in water and wastewater: a review on formation and removal, *Chemosphere*, 191 (2018) 685–703.
- [47] H. Chang, C. Chen, G. Wang, Identification of potential nitrogenous organic precursors for C-, N-DBPs and characterization of their DBPs formation, *Water Res.*, 45 (2011) 3753–3764.
- [48] H. Hu, H. Ma, L. Ding, J. Geng, K. Xu, H. Huang, Y. Zhang, H. Ren, Concentration, composition, bioavailability, and N-nitrosodimethylamine formation potential of particulate and dissolved organic nitrogen in wastewater effluents: a comparative study, *Sci. Total Environ.*, 569–570 (2016) 1359–1368.
- [49] P.A. Alaba, Y.M. Sani, S.F. Olupinla, W.M.W. Daud, I.Y. Mohammed, C.C. Enweremadu, O.O. Ayodele, Toward N-nitrosamines free water: formation, prevention, and removal, *Crit. Rev. Env. Sci. Technol.*, 47 (2018) 2448–2489.
- [50] H. Xiang, Y. Shao, N. Gao, X. Lu, N. An, W. Chu, Removal of β -cyclocitral by UV/persulfate and UV/chlorine process: degradation kinetics and DBPs formation, *Chem. Eng. J.*, 382 (2020) 122659, doi: 10.1016/j.cej.2019.122659.
- [51] D.B. Miklos, W.L. Wang, K.G. Linden, J.E. Drewes, U. Hübner, Comparison of UV-AOPs (UV/H₂O₂, UV/PDS and UV/chlorine) for TORC removal from municipal wastewater effluent and optical surrogate model evaluation, *Chem. Eng. J.*, 362 (2019) 537–547.
- [52] B.K. Mayer, E. Daugherty, M. Abbaszadegan, Evaluation of the relationship between bulk organic precursors and disinfection by-product formation for advanced oxidation processes, *Chemosphere*, 121 (2015) 39–46.
- [53] J.L. Weishaar, G.R. Aiken, B.A. Bergamaschi, M.S. Fram, R. Fujii, K. Mopper, Evaluation of specific ultraviolet absorbance as an indicator of the chemical composition and reactivity of dissolved organic carbon, *Environ. Sci. Technol.*, 37 (2003) 4702–4708.
- [54] M. Sillanpaa, M.C. Ncibi, A. Matilainen, Advanced oxidation processes for the removal of natural organic matter from drinking water sources: a comprehensive review, *J. Environ. Manage.*, 208 (2018) 56–76.
- [55] L.-C. Hua, S.-J. Chao, K. Huang, C. Huang, Characteristics of low and high SUVA precursors: relationships among molecular weight, fluorescence, and chemical composition with DBP formation, *Sci. Total Environ.*, 727 (2020) 138638, doi: 10.1016/j.scitotenv.2020.138638.
- [56] V. Yargeau, C. Leclair, Impact of operating conditions on decomposition of antibiotics during ozonation: a review, *Ozone: Sci. Eng.*, 30 (2008) 175–188.
- [57] W. Qi, H. Zhang, C. Hu, H. Liu, J. Qu, Effect of ozonation on the characteristics of effluent organic matter fractions and subsequent associations with disinfection by-products formation, *Sci. Total Environ.*, 610–611 (2018) 1057–1064.
- [58] A.D. Dotson, V.O. Keen, D. Metz, K.G. Linden, UV/H₂O₂ treatment of drinking water increases post-chlorination DBP formation, *Water Res.*, 44 (2010) 3703–3713.
- [59] B. Sun, Y. Wang, Y. Xiang, C. Shang, Influence of pre-ozonation of DOM on micropollutant abatement by UV-based advanced oxidation processes, *J. Hazard. Mater.*, 391 (2020) 122201, doi: 10.1016/j.jhazmat.2020.122201.
- [60] K.M.S. Hansen, A. Spiliotopoulou, W.A. Cheema, H.R. Andersen, Effect of ozonation of swimming pool water on formation of volatile disinfection by-products – a laboratory study, *Chem. Eng. J.*, 289 (2016) 277–285.
- [61] Q. Lin, F. Dong, C. Li, J. Cui, Disinfection by-product formation from algal organic matters after ozonation or ozone combined with activated carbon treatment with subsequent chlorination, *J. Environ. Sci.*, 104 (2021) 233–241.
- [62] P.D. Nguyen, T.D.Q. Le, N.H. Nguyen, K.T. Tran, M.T. Nguyen, K.A. Huynh, Reducing disinfection by-product precursors and chlorine consuming substances by a special integration of biofiltration and ozonation: a pilot study, *J. Water Process Eng.*, 37 (2020) 101419, doi: 10.1016/j.jwpe.2020.101419.
- [63] C.V. Rekhate, J.K. Srivastava, Recent advances in ozone-based advanced oxidation processes for treatment of wastewater – a review, *Chem. Eng. J. Advances*, 3 (2020) 100031, doi: 10.1016/j.cej.2020.100031.
- [64] G. Cheng, Z. Li, L. Sun, Y. Li, J. Fu, Application of microwave/electrodeless discharge ultraviolet/ozone sterilization technology in water reclamation, *Process Saf. Environ. Prot.*, 138 (2020) 148–156.
- [65] M. Petronijević, J. Agbaba, S. Ražić, J. Molnar Jazić, A. Tubić, M. Watson, B. Dalmacija, Fate of bromine-containing disinfection by-products precursors during ozone and ultraviolet-based advanced oxidation processes, *International Journal of Environmental Science and Technology*, 16 (2018) 171–180.
- [66] W.A. Cheema, K.M.S. Kaarsholm, H.R. Andersen, Combined UV treatment and ozonation for the removal of by-product precursors in swimming pool water, *Water Res.*, 110 (2017) 141–149.
- [67] S. Srithep, S. Phattarapattamawong, Kinetic removal of haloacetonitrile precursors by photo-based advanced oxidation processes (UV/H₂O₂, UV/O₃, and UV/H₂O₂/O₃), *Chemosphere*, 176 (2017) 25–31.
- [68] J. Agbaba, J.M. Jazić, A. Tubić, M. Watson, S. Maletić, M.K. Isakovski, B. Dalmacija, Oxidation of natural organic matter with processes involving O₃, H₂O₂ and UV light: formation of oxidation and disinfection by-products, *RSC Adv.*, 6 (2016) 86212–86219.
- [69] Y. Ren, J. Kong, J. Xue, X. Shi, H. Li, J. Qiao, Y. Lu, Effects of ozonation on the activity of endotoxin and its inhalation toxicity in reclaimed water, *Water Res.*, 154 (2019) 153–161.
- [70] W.A. Cheema, H.R. Andersen, K.M.S. Kaarsholm, Improved DBP elimination from swimming pool water by continuous combined UV and ozone treatment, *Water Res.*, 147 (2018) 214–222.
- [71] M. Nihemaiti, D.B. Miklos, U. Hubner, K.G. Linden, J.E. Drewes, J.P. Croue, Removal of trace organic chemicals in wastewater effluent by UV/H₂O₂ and UV/PDS, *Water Res.*, 145 (2018) 487–497.
- [72] M.-Y. Lee, W.-L. Wang, Y. Du, Q.-Y. Wu, N. Huang, Z.-B. Xu, H.-Y. Hu, Comparison of UV/H₂O₂ and UV/PS processes for the treatment of reverse osmosis concentrate from municipal wastewater reclamation, *Chem. Eng. J.*, 388 (2020) 124260, doi: 10.1016/j.cej.2020.124260.
- [73] S. Tak, B.P. Vellanki, Applicability of advanced oxidation processes in removing anthropogenically influenced chlorination disinfection by-product precursors in a developing country, *Ecotoxicol. Environ. Saf.*, 186 (2019) 109768, doi: 10.1016/j.ecoenv.2019.109768.
- [74] F. Qian, M. He, J. Wu, H. Yu, L. Duan, Insight into removal of dissolved organic matter in post pharmaceutical wastewater by coagulation-UV/H₂O₂, *J. Environ. Sci.*, 76 (2019) 329–338.
- [75] C.S. Lee, A.K. Venkatesan, H.W. Walker, C.J. Gobler, Impact of groundwater quality and associated by-product formation during UV/hydrogen peroxide treatment of 1,4-dioxane, *Water Res.*, 173 (2020) 115534, doi: 10.1016/j.watres.2020.115534.
- [76] H.R. Sindelar, M.T. Brown, T.H. Boyer, Evaluating UV/H₂O₂, UV/percarbonate, and UV/perborate for natural organic matter reduction from alternative water sources, *Chemosphere*, 105 (2014) 112–118.
- [77] S. Ding, F. Wang, W. Chu, C. Fang, Y. Pan, S. Lu, N. Gao, Using UV/H₂O₂ pre-oxidation combined with an optimised disinfection scenario to control CX_R-type disinfection by-product formation, *Water Res.*, 167 (2019) 115096, doi: 10.1016/j.watres.2019.115096.
- [78] A. Szczuka, N. Huang, J.A. MacDonald, A. Nayak, Z. Zhang, W.A. Mitch, N-Nitrosodimethylamine formation during UV/

- hydrogen peroxide and UV/chlorine advanced oxidation process treatment following reverse osmosis for potable reuse, *Environ. Sci. Technol.*, 54 (2020) 15465–15475.
- [79] S.L. Roback, K.P. Ishida, Y.-H. Chuang, Z. Zhang, W.A. Mitch, M.H. Plumlee, Pilot UV-AOP comparison of UV/hydrogen peroxide, UV/free chlorine, and UV/monochloramine for the removal of *N*-nitrosodimethylamine (NDMA) and NDMA precursors, *ACS EST Water*, 1 (2021) 396–406.
- [80] Z. Zhang, Y.H. Chuang, A. Szczuka, K.P. Ishida, S. Roback, M.H. Plumlee, W.A. Mitch, Pilot-scale evaluation of oxidant speciation, 1,4-dioxane degradation and disinfection by-product formation during UV/hydrogen peroxide, UV/free chlorine and UV/chloramines advanced oxidation process treatment for potable reuse, *Water Res.*, 164 (2019) 114939, doi: 10.1016/j.watres.2019.114939.
- [81] Y.H. Chuang, A. Szczuka, F. Shabani, J. Munoz, R. Aflaki, S.D. Hammond, W.A. Mitch, Pilot-scale comparison of microfiltration/reverse osmosis and ozone/biological activated carbon with UV/hydrogen peroxide or UV/free chlorine AOP treatment for controlling disinfection by-products during wastewater reuse, *Water Res.*, 152 (2019) 215–225.
- [82] Z. Yimeng, C. Wenhai, X. Ting, Y. Daqiang, X. Bin, L. Pan, A. Na, Impact of pre-oxidation using H_2O_2 and ultraviolet/ H_2O_2 on disinfection by-products generated from chlor(am)ination of chloramphenicol, *Chem. Eng. J.*, 317 (2017) 112–118.
- [83] F.X. Tian, S.X. Ma, B. Xu, X.J. Hu, H.B. Xing, J. Liu, J. Wang, Y.Y. Li, B. Wang, X. Jiang, Photochemical degradation of iodate by UV/ H_2O_2 process: kinetics, parameters and enhanced formation of iodo-trihalomethanes during chloramination, *Chemosphere*, 221 (2019) 292–300.
- [84] J. Zhang, J. Liu, C.S. He, C. Qian, Y. Mu, Formation of iodo-trihalomethanes (I-THMs) during disinfection with chlorine or chloramine: impact of UV/ H_2O_2 pre-oxidation, *Sci. Total Environ.*, 640–641 (2018) 764–771.
- [85] L. Cai, L. Li, S. Yu, J. Guo, S. Kupperts, L. Dong, Formation of odorous by-products during chlorination of major amino acids in East Taihu Lake: impacts of UV, UV/PS and UV/ H_2O_2 pre-treatments, *Water Res.*, 162 (2019) 427–436.
- [86] N.H. Ince, D.T. Gönenç, Treatability of a textile azo dye by UV/ H_2O_2 , *Environ. Technol.*, 18 (1997) 179–185.
- [87] B.R. Moon, T.K. Kim, M.K. Kim, J. Choi, K.D. Zoh, Degradation mechanisms of Microcystin-LR during UV-B photolysis and UV/ H_2O_2 processes: by-products and pathways, *Chemosphere*, 185 (2017) 1039–1047.
- [88] I. Gultekin, N.H. Ince, Degradation of reactive azo dyes by UV/ H_2O_2 : impact of radical scavengers, *J. Environ. Sci. Health. Part A Toxic/Hazard. Subst. Environ. Eng.*, 39 (2004) 1069–1081.
- [89] J.A. Khan, X. He, H.M. Khan, N.S. Shah, D.D. Dionysiou, Oxidative degradation of atrazine in aqueous solution by UV/ H_2O_2 /Fe²⁺, UV//Fe²⁺ and UV//Fe²⁺ processes: a comparative study, *Chem. Eng. J.*, 218 (2013) 376–383.
- [90] C. Amor, J.R. Fernandes, M.S. Lucas, J.A. Peres, Hydroxyl and sulfate radical advanced oxidation processes: application to an agro-industrial wastewater, *Environ. Technol. Innovation*, 21 (2020) 101183, doi: 10.1016/j.eti.2020.101183.
- [91] Y. Fu, G. Wu, J. Geng, J. Li, S. Li, H. Ren, Kinetics and modeling of artificial sweeteners degradation in wastewater by the UV/persulfate process, *Water Res.*, 150 (2019) 12–20.
- [92] J. Wang, S. Wang, Activation of persulfate (PS) and peroxymonosulfate (PMS) and application for the degradation of emerging contaminants, *Chem. Eng. J.*, 334 (2018) 1502–1517.
- [93] F. Wang, W. Wang, S. Yuan, W. Wang, Z.-H. Hu, Comparison of UV/ H_2O_2 and UV/PS processes for the degradation of thiamphenicol in aqueous solution, *J. Photochem. Photobiol., A*, 348 (2017) 79–88.
- [94] S. Canonica, T. Kohn, M. Mac, F.J. Real, J. Wirz, U. von Gunten, Photosensitizer method to determine rate constants for the reaction of carbonate radical with organic compounds, *Environ. Sci. Technol.*, 39 (2005) 9182–9188.
- [95] L. Zhou, Sulfate-radical induced removal of organic micropollutants from aqueous solution-influence of natural water constituents, *Catalysis*, (2017).
- [96] Q. Wang, Y. Shao, N. Gao, W. Chu, J. Chen, X. Lu, Y. Zhu, N. An, Impact of preoxidation of UV/persulfate on disinfection by-products by chlorination of 2,4-di-tert-butylphenol, *J. Hazard. Mater.*, 358 (2018) 450–458.
- [97] Z. Hua, X. Kong, S. Hou, S. Zou, X. Xu, H. Huang, J. Fang, DBP alteration from NOM and model compounds after UV/persulfate treatment with post chlorination, *Water Res.*, 158 (2019) 237–245.
- [98] W. Chu, D. Li, Y. Deng, N. Gao, Y. Zhang, Y. Zhu, Effects of UV/PS and UV/ H_2O_2 pre-oxidations on the formation of trihalomethanes and haloacetonitriles during chlorination and chloramination of free amino acids and short oligopeptides, *Chem. Eng. J.*, 301 (2016) 65–72.
- [99] S. Giannakis, K.-Y.A. Lin, F. Ghanbari, A review of the recent advances on the treatment of industrial wastewaters by sulfate radical-based advanced oxidation processes (SR-AOPs), *Chem. Eng. J.*, 406 (2021) 127083, doi: 10.1016/j.cej.2020.127083.
- [100] L. Bu, J. Sun, Y. Wu, W. Zhang, X. Duan, S. Zhou, D.D. Dionysiou, J.C. Crittenden, Non-negligible risk of chloropicrin formation during chlorination with the UV/persulfate pretreatment process in the presence of low concentrations of nitrite, *Water Res.*, 168 (2020) 115194, doi: 10.1016/j.watres.2019.115194.
- [101] Y.Q. Gao, N.Y. Gao, W.H. Chu, Y.F. Zhang, J. Zhang, D.Q. Yin, UV-activated persulfate oxidation of sulfamethoxypyridazine: kinetics, degradation pathways and impact on DBP formation during subsequent chlorination, *Chem. Eng. J.*, 370 (2019) 706–715.
- [102] B. Kose-Mutlu, Natural organic matter and sulphate elimination from rainwater with nanofiltration technology and process optimisation using response surface methodology, *Water Sci. Technol.*, 83 (2021) 580–594.
- [103] F.P. Chaves, G. Gomes, A. Della-Flora, A. Dallegrave, C. Sirtori, E.M. Saggiaro, D.M. Bila, Comparative endocrine disrupting compound removal from real wastewater by UV/Cl and UV/ H_2O_2 : effect of pH, estrogenic activity, transformation products and toxicity, *Sci. Total Environ.*, 746 (2020) 141041, doi: 10.1016/j.scitotenv.2020.141041.
- [104] C. Wang, N. Moore, K. Bircher, S. Andrews, R. Hofmann, Full-scale comparison of UV/ H_2O_2 and UV/Cl₂ advanced oxidation: the degradation of micropollutant surrogates and the formation of disinfection by-products, *Water Res.*, 161 (2019) 448–458.
- [105] A. Belghit, S. Merouani, O. Hamdaoui, A. Alghyamah, M. Bouhelassa, Influence of processing conditions on the synergism between UV irradiation and chlorine toward the degradation of refractory organic pollutants in UV/chlorine advanced oxidation system, *Sci. Total Environ.*, 736 (2020) 139623, doi: 10.1016/j.scitotenv.2020.139623.
- [106] W.L. Wang, X. Zhang, Q.Y. Wu, Y. Du, H.Y. Hu, Degradation of natural organic matter by UV/chlorine oxidation: molecular decomposition, formation of oxidation by-products and cytotoxicity, *Water Res.*, 124 (2017) 251–258.
- [107] J. Sun, D. Kong, E. Aghdam, J. Fang, Q. Wu, J. Liu, Y. Du, X. Yang, C. Shang, The influence of the UV/chlorine advanced oxidation of natural organic matter for micropollutant degradation on the formation of DBPs and toxicity during post-chlorination, *Chem. Eng. J.*, 373 (2019) 870–879.
- [108] X. Yang, J. Sun, W. Fu, C. Shang, Y. Li, Y. Chen, W. Gan, J. Fang, PPCP degradation by UV/chlorine treatment and its impact on DBP formation potential in real waters, *Water Res.*, 98 (2016) 309–318.
- [109] Z. Hua, D. Li, Z. Wu, D. Wang, Y. Cui, X. Huang, J. Fang, T. An, DBP formation and toxicity alteration during UV/chlorine treatment of wastewater and the effects of ammonia and bromide, *Water Res.*, 188 (2021) 116549, doi: 10.1016/j.watres.2020.116549.
- [110] D. Wang, J.R. Bolton, S.A. Andrews, R. Hofmann, Formation of disinfection by-products in the ultraviolet/chlorine advanced oxidation process, *Sci. Total Environ.*, 518 (2015) 49–57.
- [111] L. Bu, S. Zhou, S. Zhu, Y. Wu, X. Duan, Z. Shi, D.D. Dionysiou, Insight into carbamazepine degradation

- by UV/monochloramine: reaction mechanism, oxidation products, and DBPs formation, *Water Res.*, 146 (2018) 288–297.
- [112] Z. Liu, B. Xu, T.Y. Zhang, C.Y. Hu, Y.L. Tang, Z.Y. Dong, T.C. Cao, M.G. El-Din, Formation of disinfection by-products in a UV-activated mixed chlorine/chloramine system, *J. Hazard. Mater.*, 407 (2020) 124373, doi: 10.1016/j.jhazmat.2020.124373.
- [113] Z.C. Gao, Y.L. Lin, B. Xu, Y. Xia, C.Y. Hu, T.Y. Zhang, H. Qian, T.C. Cao, N.Y. Gao, Effect of bromide and iodide on halogenated by-product formation from different organic precursors during UV/chlorine processes, *Water Res.*, 182 (2020) 116035, doi: 10.1016/j.watres.2020.116035.
- [114] F. Dong, Q. Lin, C. Li, L. Wang, A. García, UV/chlorination process of algal-laden water: algal inactivation and disinfection by-products attenuation, *Sep. Purif. Technol.*, 257 (2021) 117896, doi: 10.1016/j.seppur.2020.117896.
- [115] H. Millh, X. Yu, D. Cabooter, R. Dewil, Degradation of ciprofloxacin using UV-based advanced removal processes: comparison of persulfate-based advanced oxidation and sulfite-based advanced reduction processes, *Sci. Total Environ.*, 764 (2020) 144510, doi: 10.1016/j.scitotenv.2020.144510.
- [116] X. Gan, T. Karanfil, S.S. Kaplan Bekaroglu, J. Shan, The control of N-DBP and C-DBP precursors with MIEX(R), *Water Res.*, 47 (2013) 1344–1352.
- [117] R. Andreozzi, I. Di Somma, A. Pollio, G. Pinto, R. Sanchirico, Toxicity of unwanted intermediates and products formed during accidental thermal decomposition of chemicals, *J. Hazard. Mater.*, 150 (2008) 433–437.
- [118] X. Xu, J. Chen, R. Qu, Z. Wang, Oxidation of tris(2-chloroethyl) phosphate in aqueous solution by UV-activated peroxymonosulfate: kinetics, water matrix effects, degradation products and reaction pathways, *Chemosphere*, 185 (2017) 833–843.
- [119] T. Zeng, M.J. Plewa, W.A. Mitch, N-nitrosamines and halogenated disinfection by-products in U.S. full advanced treatment trains for potable reuse, *Water Res.*, 101 (2016) 176–186.
- [120] S. Kali, M. Khan, M.S. Ghaffar, S. Rasheed, A. Waseem, M.M. Iqbal, M. Bilal Khan Niazi, M.I. Zafar, Occurrence, influencing factors, toxicity, regulations, and abatement approaches for disinfection by-products in chlorinated drinking water: a comprehensive review, *Environ. Pollut.*, 281 (2021) 116950, doi: 10.1016/j.envpol.2021.116950.
- [121] G.V. Buxton, C.L. Greenstock, W.P. Helman, A.B. Ross, Critical Review of rate constants for reactions of hydrated electrons, hydrogen atoms and hydroxyl radicals ($\cdot\text{OH}/\cdot\text{O}^-$ in aqueous solution), *J. Phys. Chem. Ref. Data*, 17 (1988) 513–886.
- [122] Y. Qi, R. Qu, J. Liu, J. Chen, G. Al-Basher, N. Alsultan, Z. Wang, Z. Huo, Oxidation of flumequine in aqueous solution by UV-activated peroxymonosulfate: kinetics, water matrix effects, degradation products and reaction pathways, *Chemosphere*, 237 (2019) 124484, doi: 10.1016/j.chemosphere.2019.124484.
- [123] R.E. Huie, C.L. Clifton, Temperature dependence of the rate constants for reactions of the sulfate radical, $\text{SO}_4^{\cdot-}$, with anions, *J. Phys. Chem.*, 94 (1990) 8561–8567.
- [124] Z.H. Zuo, Z.L. Cai, Y. Katsumura, N. Chitose, Y. Muroya, Reinvestigation of the acid–base equilibrium of the (bi) carbonate radical and pH dependence of its reactivity with inorganic reactants, *Radiat. Phys. Chem.*, 55 (1999) 15–23.
- [125] B.M. Matthew, C. Anastasio, A chemical probe technique for the determination of reactive halogen species in aqueous solution: part 1 - bromide solutions, *Atmos. Chem. Phys.*, 6 (2006) 2423–2437.
- [126] B.G. Ershov, Kinetics, mechanism and intermediates of some radiation-induced reactions in aqueous solutions, *Russ. Chem. Rev.*, 73 (2004) 101–113.
- [127] G.R. Peyton, The free-radical chemistry of persulfate-based total organic carbon analyzers, *Mar. Chem.*, 41 (1993) 91–103.
- [128] S. Waclawek, H.V. Lutze, K. Grübel, V.V.T. Padil, M. Černík, D.D. Dionysiou, Chemistry of persulfates in water and wastewater treatment: a review, *Chem. Eng. J.*, 330 (2017) 44–62.
- [129] R.J. Zehavi, Oxidation of aqueous bromide ions by hydroxyl radicals-pulse radiolytic investigation, *J. Phys. Chem.*, 76 (1972) 312–319.
- [130] X. Liu, Y. Liu, S. Lu, Z. Wang, Y. Wang, G. Zhang, X. Guo, W. Guo, T. Zhang, B. Xi, Degradation difference of ofloxacin and levofloxacin by UV/ H_2O_2 and UV/PS (persulfate): efficiency, factors and mechanism, *Chem. Eng. J.*, 385 (2020) 123987, doi: 10.1016/j.cej.2019.123987.
- [131] C. Chen, Z. Wu, S. Zheng, L. Wang, X. Niu, J. Fang, Comparative study for interactions of sulfate radical and hydroxyl radical with phenol in the presence of nitrite, *Environ. Sci. Technol.*, 54 (2020) 8455–8463.
- [132] B. Nikraves, A. Shomalnasab, A. Nayyer, N. Aghababaei, R. Zarebi, F. Ghanbari, UV/Chlorine process for dye degradation in aqueous solution: mechanism, affecting factors and toxicity evaluation for textile wastewater, *J. Environ. Chem. Eng.*, 8 (2020) 104244, doi: 10.1016/j.jece.2020.104244.
- [133] L. Qin, Y.L. Lin, B. Xu, C.Y. Hu, F.X. Tian, T.Y. Zhang, W.Q. Zhu, H. Huang, N.Y. Gao, Kinetic models and pathways of ronidazole degradation by chlorination, UV irradiation and UV/chlorine processes, *Water Res.*, 65 (2014) 271–81.
- [134] Z.B. Guo, Y.L. Lin, B. Xu, H. Huang, T.Y. Zhang, F.X. Tian, N.Y. Gao, Degradation of chlortoluron during UV irradiation and UV/chlorine processes and formation of disinfection by-products in sequential chlorination, *Chem. Eng. J.*, 283 (2016) 412–419.
- [135] P. Sun, W.N. Lee, R. Zhang, C.H. Huang, Degradation of DEET and caffeine under UV/chlorine and simulated sunlight/chlorine conditions, *Environ. Sci. Technol.*, 50 (2016) 13265–13273.
- [136] C.K. Remucal, D. Manley, Emerging investigators series: the efficacy of chlorine photolysis as an advanced oxidation process for drinking water treatment, *Environ. Sci. Water Res. Technol.*, 2 (2016) 565–579.
- [137] F. Zohra Meghlaoui, S. Merouani, O. Hamdaoui, M. Bouhelassa, M. Ashokkumar, Rapid catalytic degradation of refractory textile dyes in Fe(II)/chlorine system at near neutral pH: radical mechanism involving chlorine radical anion ($\text{Cl}_2^{\cdot-}$)-mediated transformation pathways and impact of environmental matrices, *Sep. Purif. Technol.*, 227 (2019) 115685, doi: 10.1016/j.seppur.2019.115685.
- [138] P. Neta, R.E. Huie, A.B. Ross, Rate constants for reactions of inorganic radicals in aqueous solution, *J. Phys. Chem.*, 17 (1988) 1027–1284.
- [139] R. Zhang, P. Sun, T.H. Boyer, L. Zhao, C.H. Huang, Degradation of pharmaceuticals and metabolite in synthetic human urine by UV, UV/ H_2O_2 and UV/PDS, *Environ. Sci. Technol.*, 49 (2015) 3056–66.
- [140] P. Xie, J. Ma, W. Liu, J. Zou, S. Yue, X. Li, M.R. Wiesner, J. Fang, Removal of 2-MIB and geosmin using UV/persulfate: contributions of hydroxyl and sulfate radicals, *Water Res.*, 69 (2015) 223–233.
- [141] T. Beitz, W. Bechmann, R. Mitzner, Investigations of reactions of selected azaarenes with radicals in water, *J. Phys. Chem. A*, 102 (1998) 6766–6771.
- [142] X. Lu, Y. Shao, N. Gao, J. Chen, H. Deng, W. Chu, N. An, F. Peng, Investigation of clofibric acid removal by UV/persulfate and UV/chlorine processes: kinetics and formation of disinfection by-products during subsequent chlor(am)ination, *Chem. Eng. J.*, 331 (2018) 364–371.
- [143] Z. Chen, J. Fang, C. Fan, C. Shang, Oxidative degradation of N-Nitrosopyrrolidine by the ozone/UV process: kinetics and pathways, *Chemosphere*, 150 (2016) 731–739.
- [144] H. Mestankova, K. Schirmer, S. Canonica, U. von Gunten, Development of mutagenicity during degradation of N-nitrosamines by advanced oxidation processes, *Water Res.*, 66 (2014) 399–410.
- [145] O. Rozas, C. Vidal, C. Baeza, W.F. Jardim, A. Rossner, H.D. Mansilla, Organic micropollutants (OMPs) in natural waters: oxidation by UV/ H_2O_2 treatment and toxicity assessment, *Water Res.*, 98 (2016) 109–18.
- [146] Z. Wang, Y. Shao, N. Gao, N. An, Degradation kinetic of dibutyl phthalate (DBP) by sulfate radical- and hydroxyl radical-based advanced oxidation process in UV/persulfate system, *Sep. Purif. Technol.*, 195 (2018) 92–100.